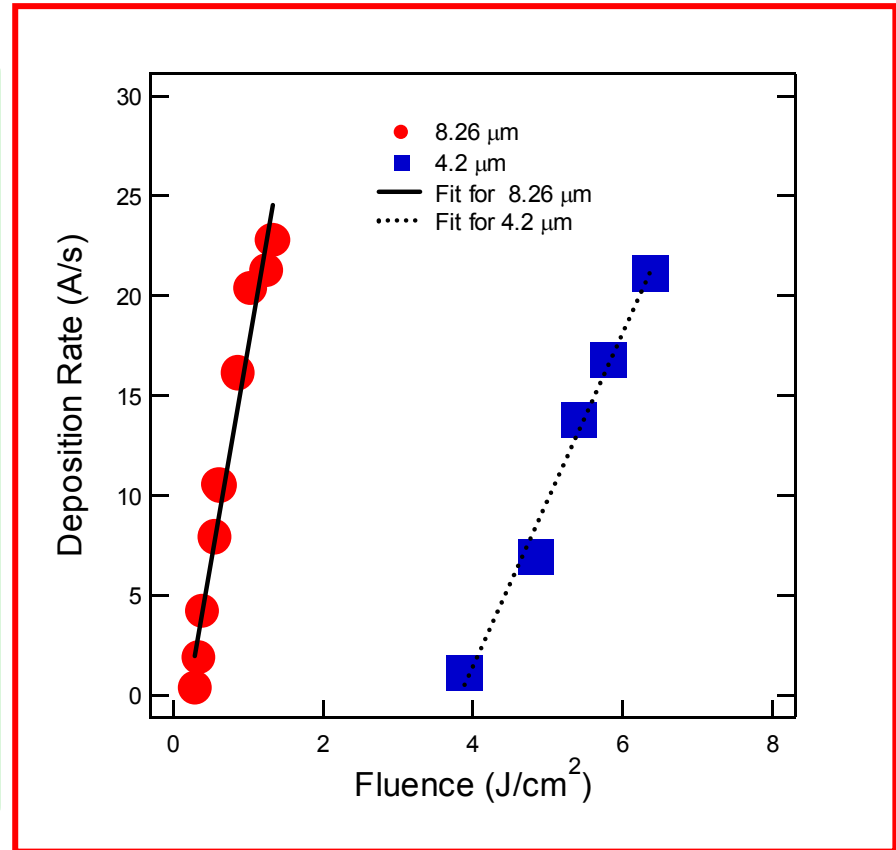
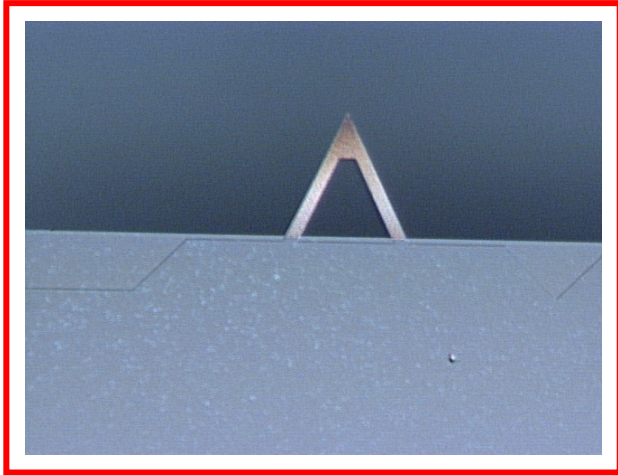


IR pulsed laser deposition: electronics, biotechnology, sensors, opto-electronics





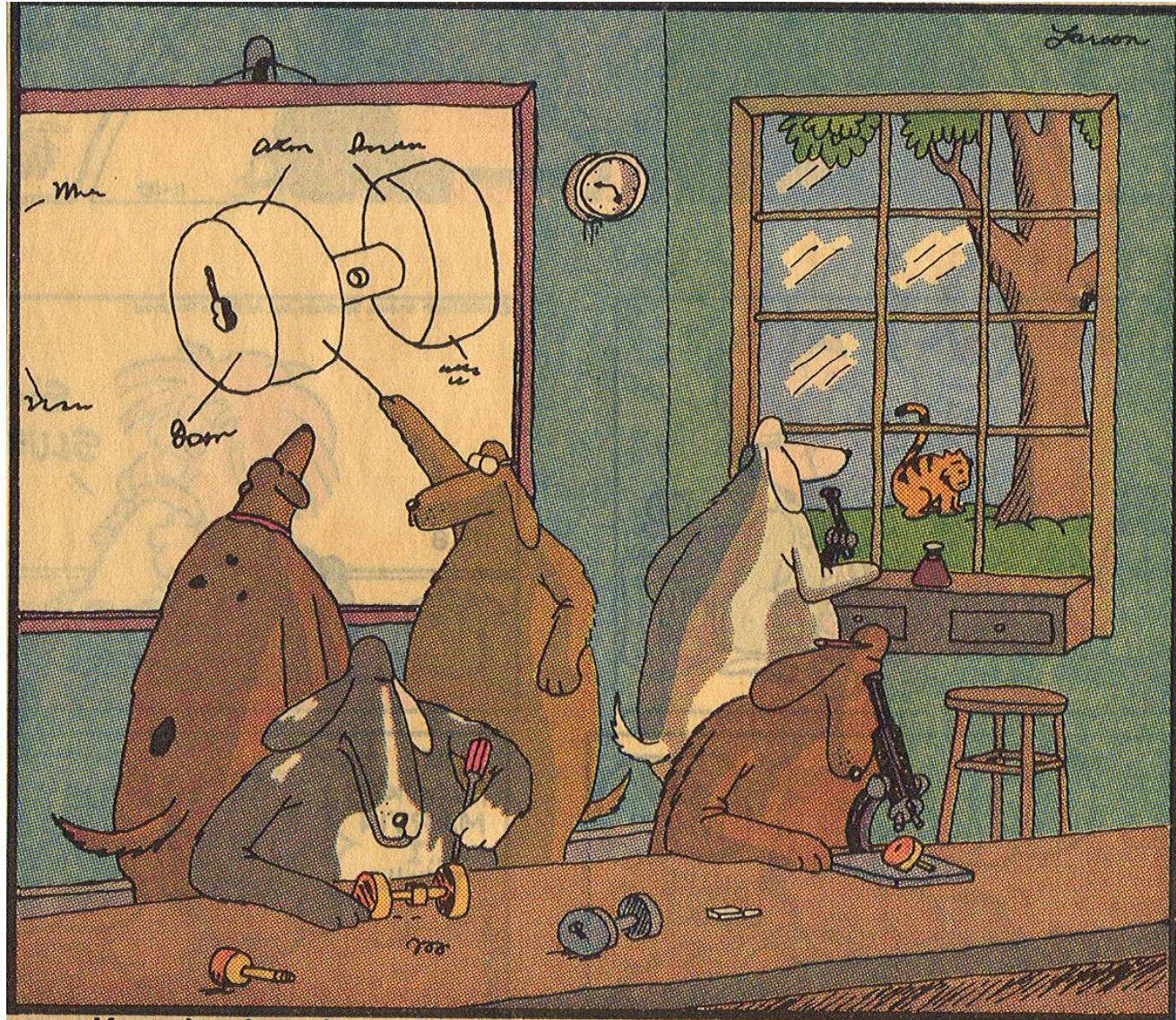
"Construction of an oscillator for any given radiation frequency will greatly extend the region of application of lasers. It is clear that if we make a laser with a sweep frequency, we apparently shall be able to influence a molecule in such a way that definite bonds will be excited and, thus, **chemical reactions will take place** in certain directions.

"However, this problem will not be simple even after design of the appropriate lasers. But one thing is clear: the problem is extremely interesting and perhaps its solution will be able to make a revolution in a series of branches of chemical industry."

A. M. Prokhorov, Nobel Lecture, December 11, 1964

What if the effect of exciting specific bonds is not chemical?

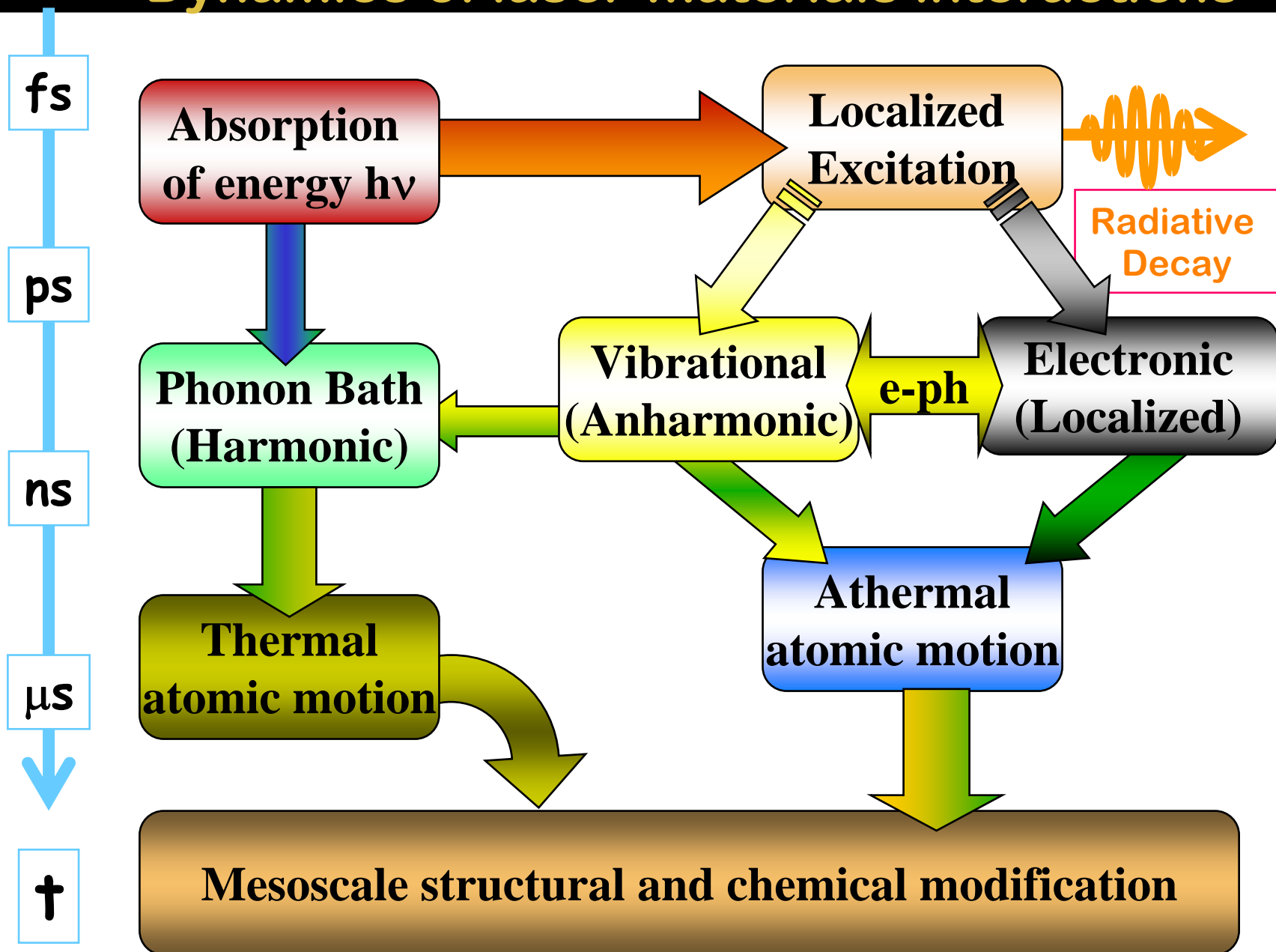
Is ps IR laser ablation a thermal process?



Knowing how it could change the lives of canines everywhere, the dog scientists struggled diligently to understand the Doorknob Principle.

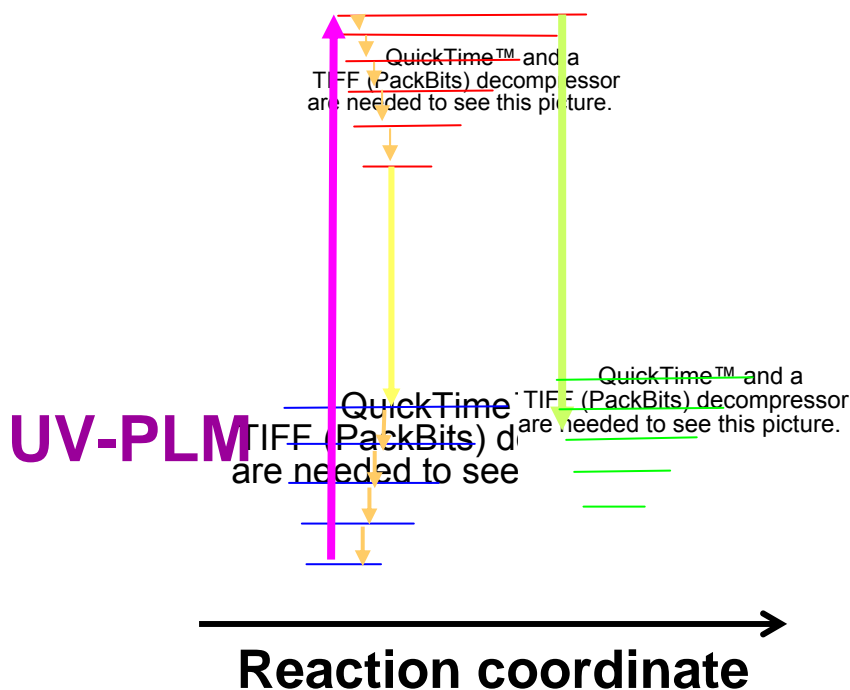
- A new paradigm: resonant infrared pulsed laser deposition (RIR-PLD) of polymers
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 - Biomedical applications: PEG, PLGA, Teflon
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 - Electronic applications: Polyimide
 - Opto-electronic applications: MEH-PPV
- Evidence for low-temperature, non-thermal character of RIR-PLD ... and some thoughts about a substitute for the FEL

Dynamics of laser-materials interactions

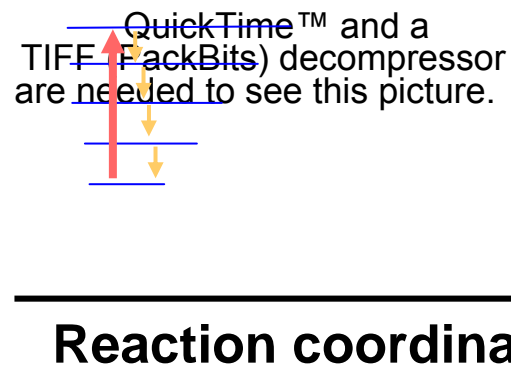


A novel paradigm for materials modification

- UV-visible-NIR processing begins with *electronic* excitation — but many materials modifications require *vibrational* energy.
- Relaxation of UV-visible-NIR energy often leads to undesirable, photolytic or photochemical products.



IR-PLM



- Requires an ablation process which
 - Produces vapor, rather than particulates or clusters
 - Localizes vibrational energy long enough to break bonds
 - Converts photon energy into desired material modification
- Efficiency requires spatio-temporal energy localization:
 - Thermal confinement $\tau_L < L_{opt}^2 / D_T$ and/or
 - Mechanical or stress confinement $\tau_L \leq L_{opt} / C_s$
 - Minimal “leakage” of energy into heat (phonons), defect formation
- The processing rate and total yield are

$$\frac{dn_{\text{proc}}}{dt} = \eta n_{\text{target}} \sigma_{(k)} I^k \Rightarrow n_{\text{proc}} \propto \frac{E_{\text{abs}}}{V} \propto F_{\text{abs}} \alpha(\omega, I)$$

- In the IR, the process yield is frequency and intensity-dependent!

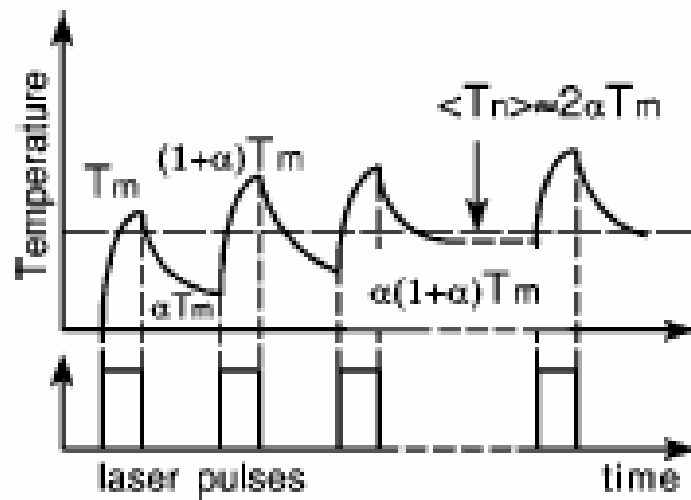
Why ultrashort, high repetition rate pulses?

- Need to deliver laser energy before thermal confinement breaks down and heat diffuses - so ...
- Use ultrashort, low energy pulses ($\leq 1-5$ ps, $3-15$ μJ) to generate a high density of vibrationally excited states, and
- Run at high pulse-repetition frequencies for efficient processing (high through-put) of material.

$$T_{\max} = \sqrt{\frac{2}{\pi} \frac{I_{\text{abs}} (D_{\text{therm}} \tau_L)^{1/2}}{\kappa}}$$

After n pulses, T is

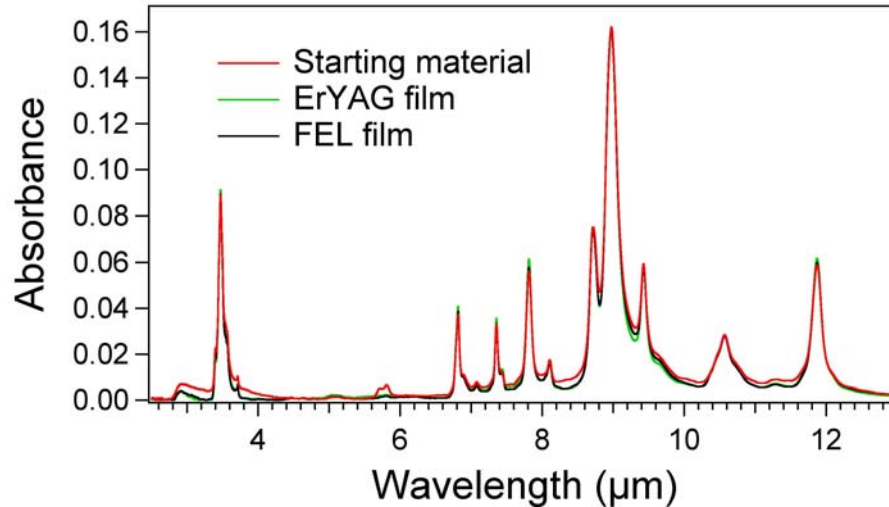
$$T_n = 2T_{\max} \sqrt{\tau_L \cdot \nu_{\text{PRF}}}$$



Ergo, low temperature, high yield!

Gamaly, Rode, Luther-Davies, J. Appl. Phys. **85**, 4213 (1999)

Why a tunable, mid-IR laser?



Er:YSGG
2.79 μm

Er:YAG
2.94 μm

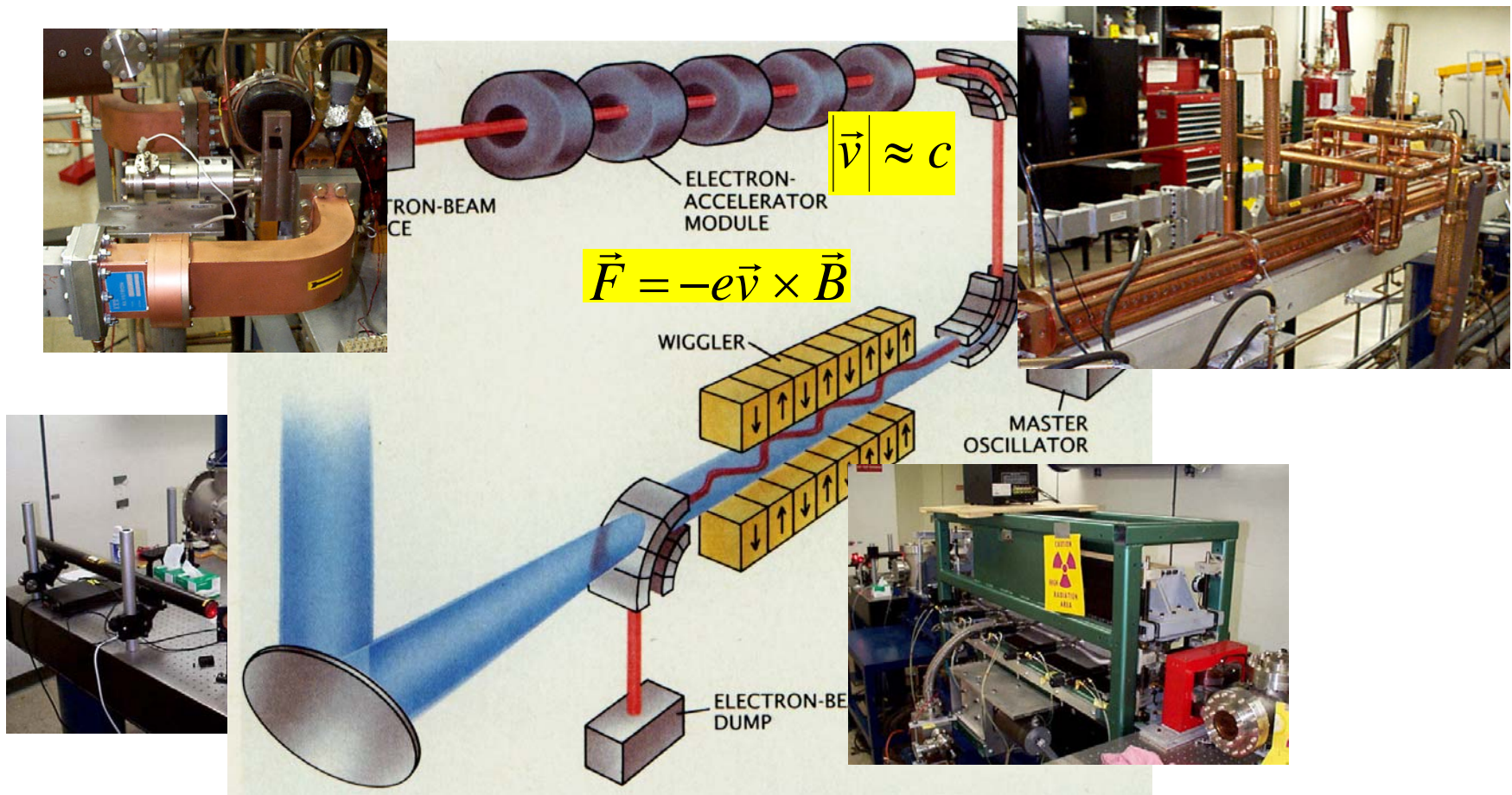
CO₂
9.4-10.6 μm

OPO
(1.5-4.0 μm)

Vanderbilt rf-linac FEL
1.8-10.2 μm

- Many organic and inorganic materials have rich vibrational spectra in the 1-10 μm region
- Tuning wavelength means controlling *density of vibrational excitation* in the absorption zone
- Tuning *may* limit **selective pathways** for laser energy
- BUT fixed frequency IR lasers do not cover many vibrational bands of interest, and
- Solid-state laser devices (e.g., OPOs, OPAs) still have limited tuning range, fluence, intensity

The two-minute FEL primer

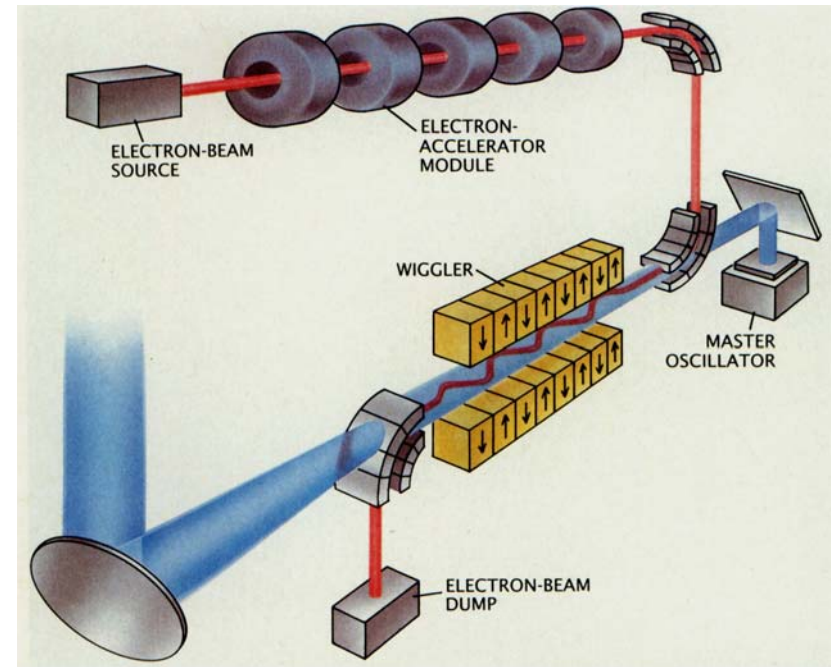
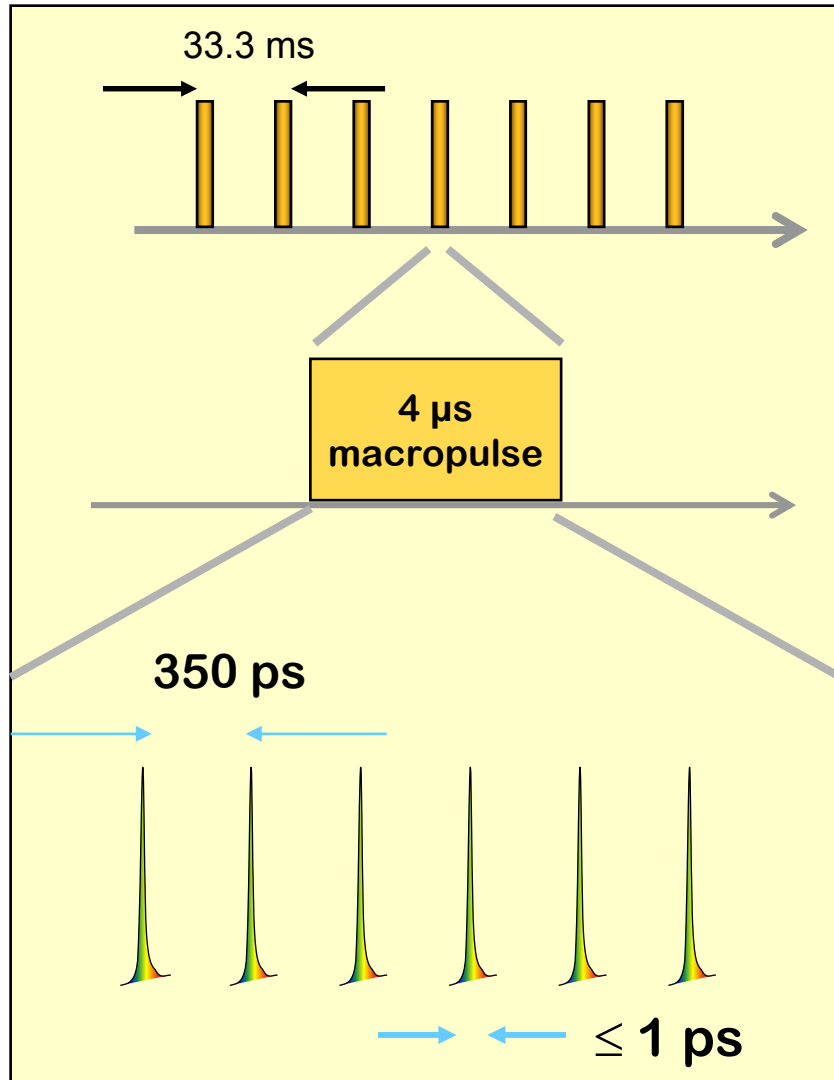


$$\lambda_{FEL} = \frac{\lambda_{Wiggler}}{2\gamma^2} \left[1 + \kappa^2(B) \right] \quad \gamma = \frac{E_{beam}}{m_0 c^2} \approx 80$$

$$\Rightarrow 2 \mu\text{m} \leq \lambda_{FEL} \leq 10 \mu\text{m}$$



“To him who has a hammer, ...”



Tuning range 2-10 μm
Macropulse energy 30-150 mJ
Micropulse energy 3-15 μJ
Spot size $\sim 10^{-2}$ - 10^{-4} cm²
Switched macropulse 50-4000 ns



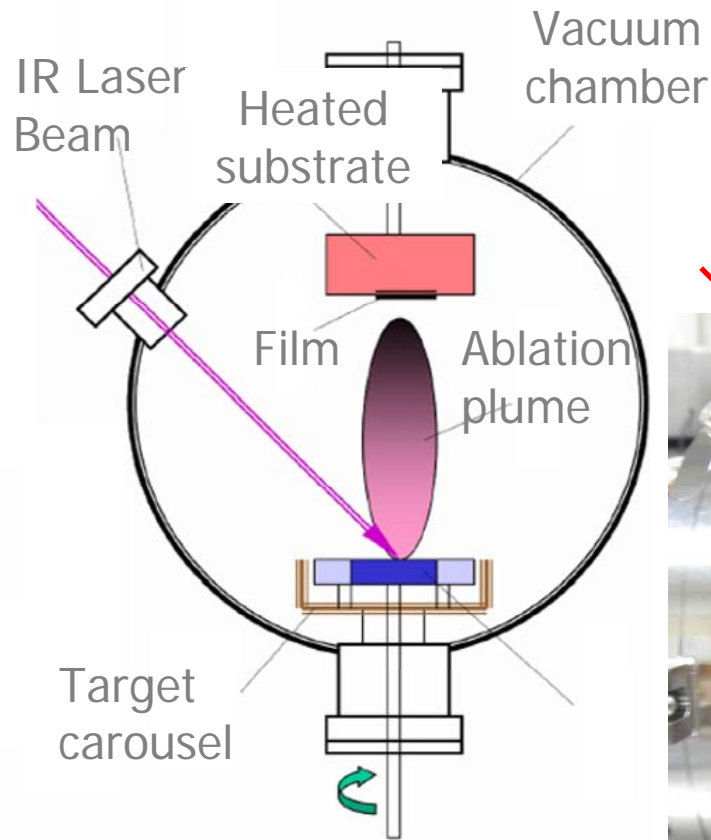
FEL irradiation parameters

	Micropulse	Macropulse
Pulse duration	1 ps	4 μ s
Pulse energy	1-30 μ J	10-300 mJ
Fluence	$\leq 5 \times 10^{-3}$ J \cdot cm $^{-2}$	—
Intensity	1-10 $\times 10^9$ W \cdot cm $^{-2}$	—
Photon flux	$\leq 5 \times 10^{29}$ cm $^{-2}$ s $^{-1}$	
Photon density*	$\leq 5 \times 10^{22}$ cm $^{-3}$	
Dose		1-100 J/cm 2

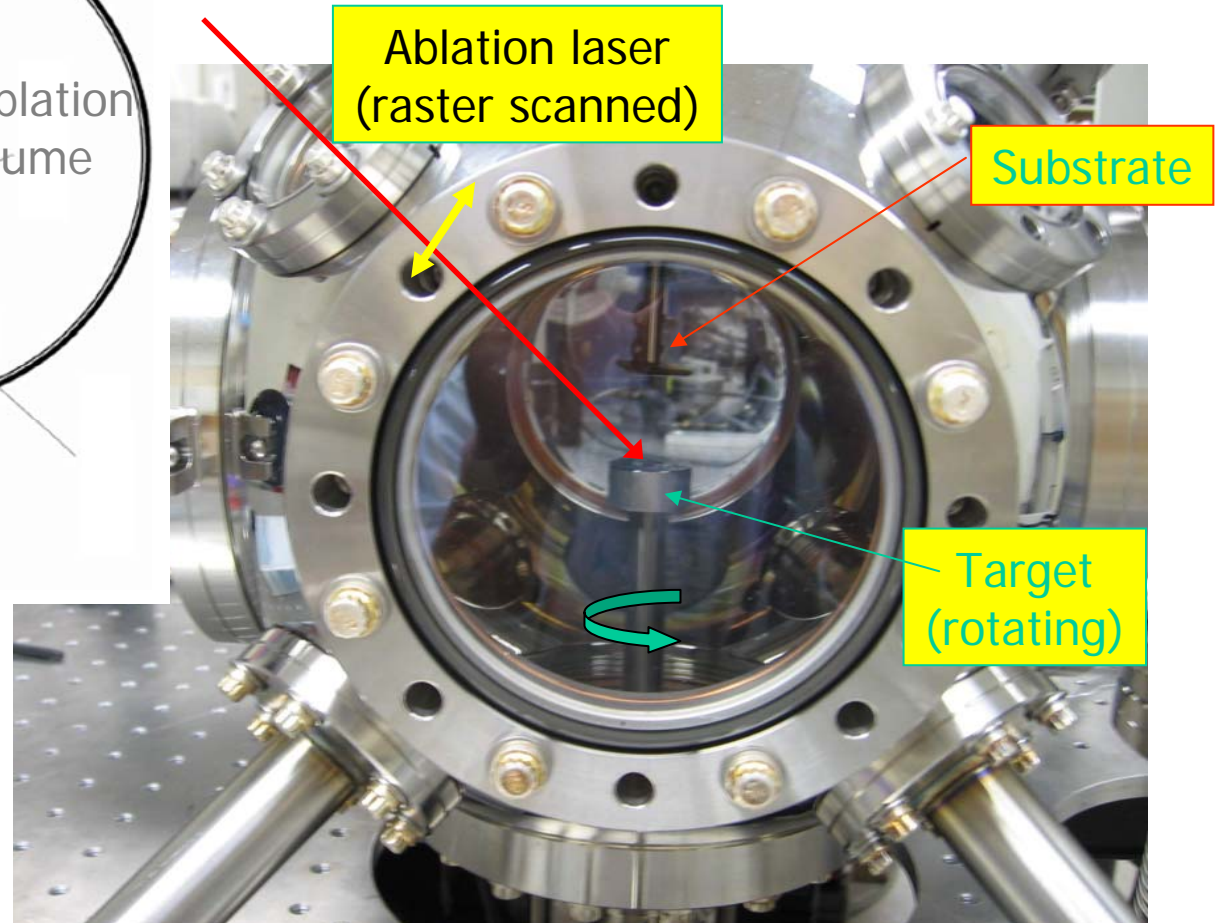
* Scales with absorption (penetration depth)!



Experimental geometry



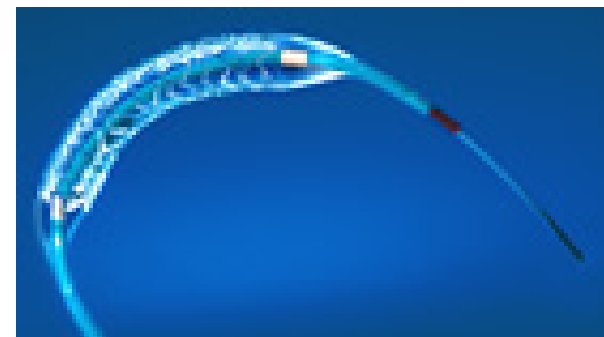
Thin-film deposition
by pulsed laser evaporation.



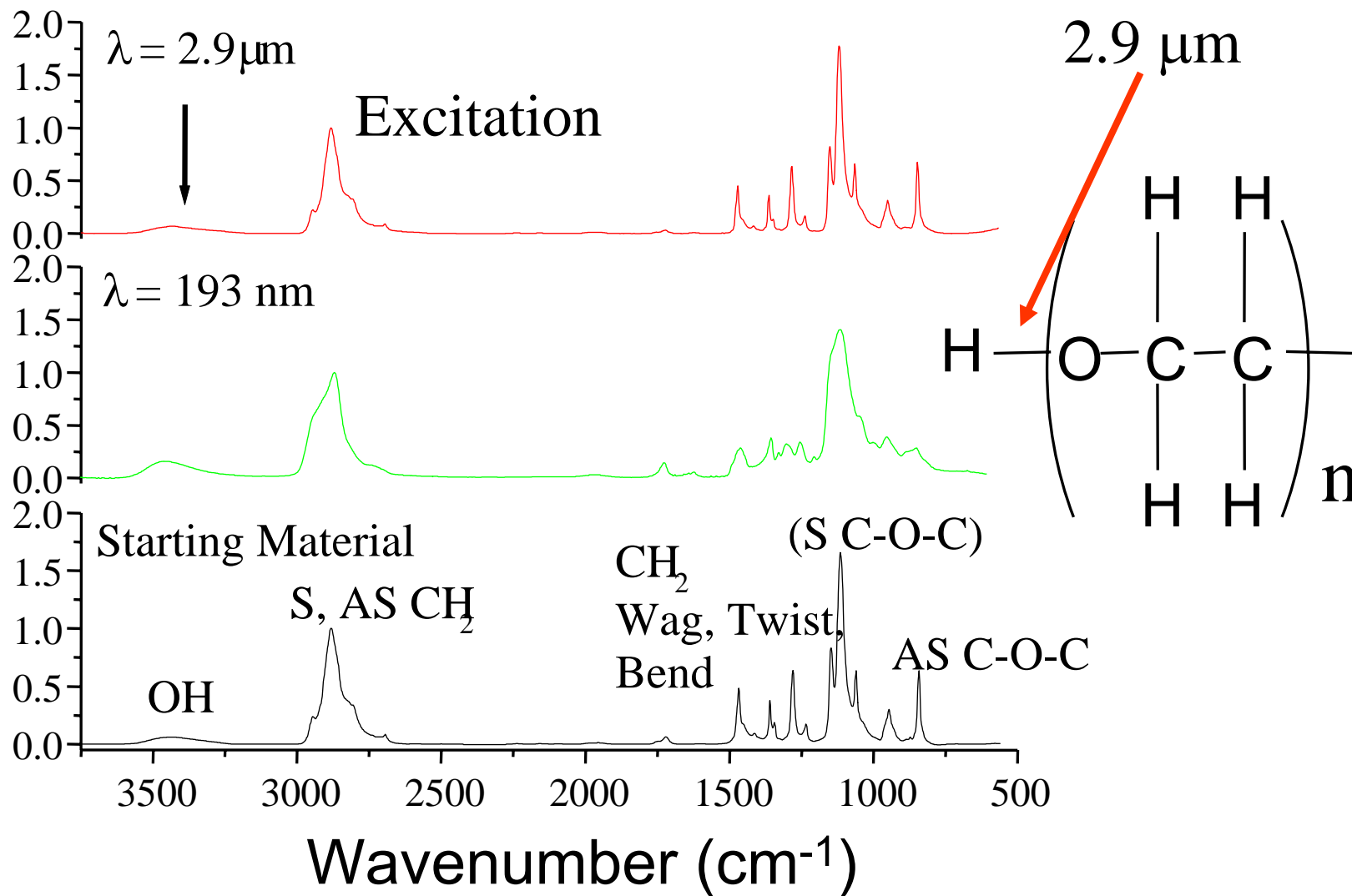
- A new paradigm: resonant infrared pulsed laser deposition (RIR-PLD) of polymers
- Some case studies ...
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 - Sensors: fluoropolyol, SXFA
 - Electronic applications: Polyimide
 - Opto-electronic applications: MEH-PPV
- Evidence for low-temperature, non-thermal character of RIR-PLD ... and some thoughts about a substitute for the FEL

Thin films for biomedical technology

- Applications: drug delivery, medical device packaging, biodegradable coatings, temporary use objects, ... and micro-electro-mechanical systems (MEMS)
- Requirements: precise thickness control to manage release time, coat irregular shapes (conformal coating), deliver functionalized moieties
- RIR-PLD shown to work on several interesting systems: PEG, PLGA, Teflon[®], ...



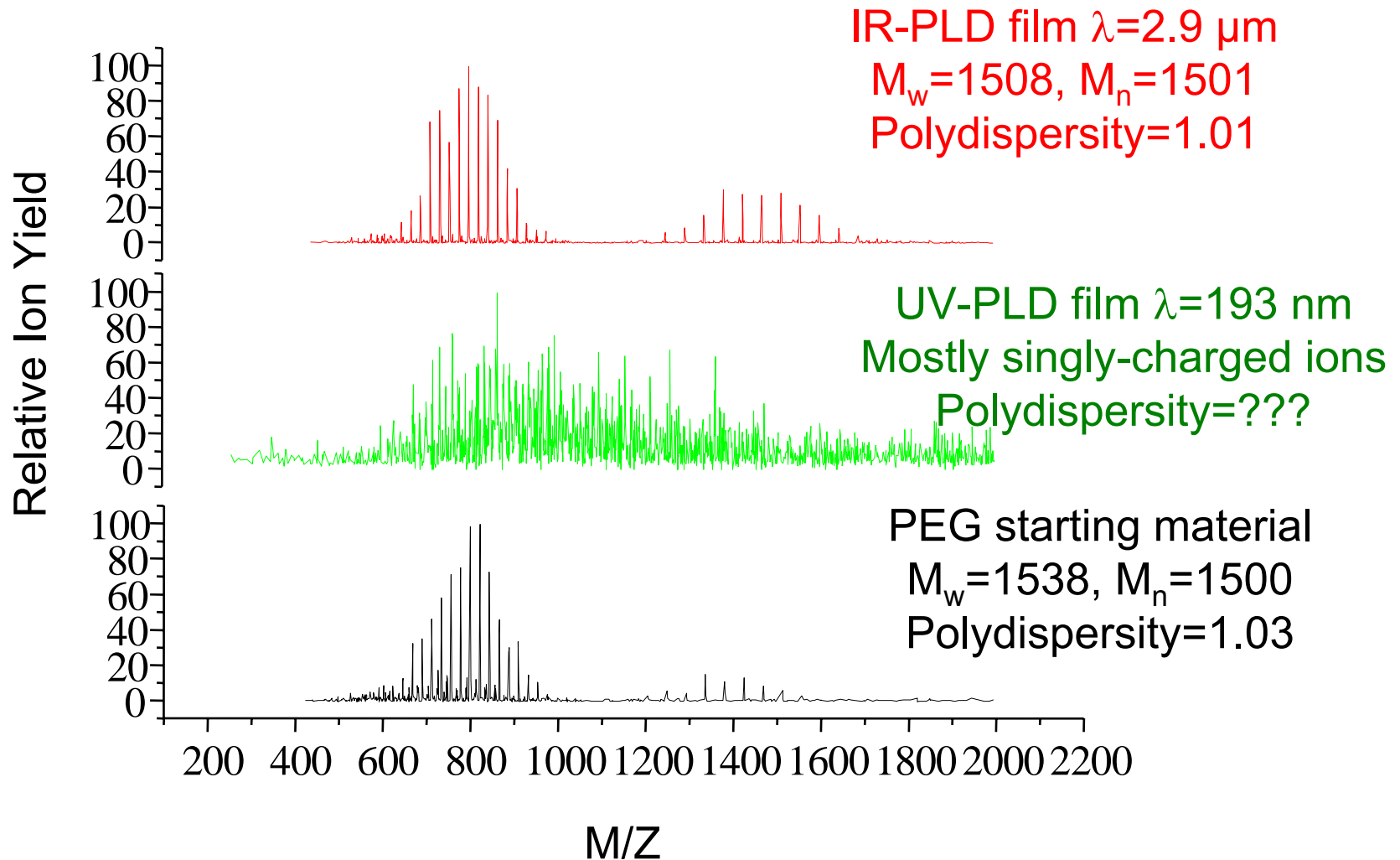
First try: PEG (1500 MW)





UV PLD is tough on polymers

Electrospray ionization mass spectra of PEG (1450) films



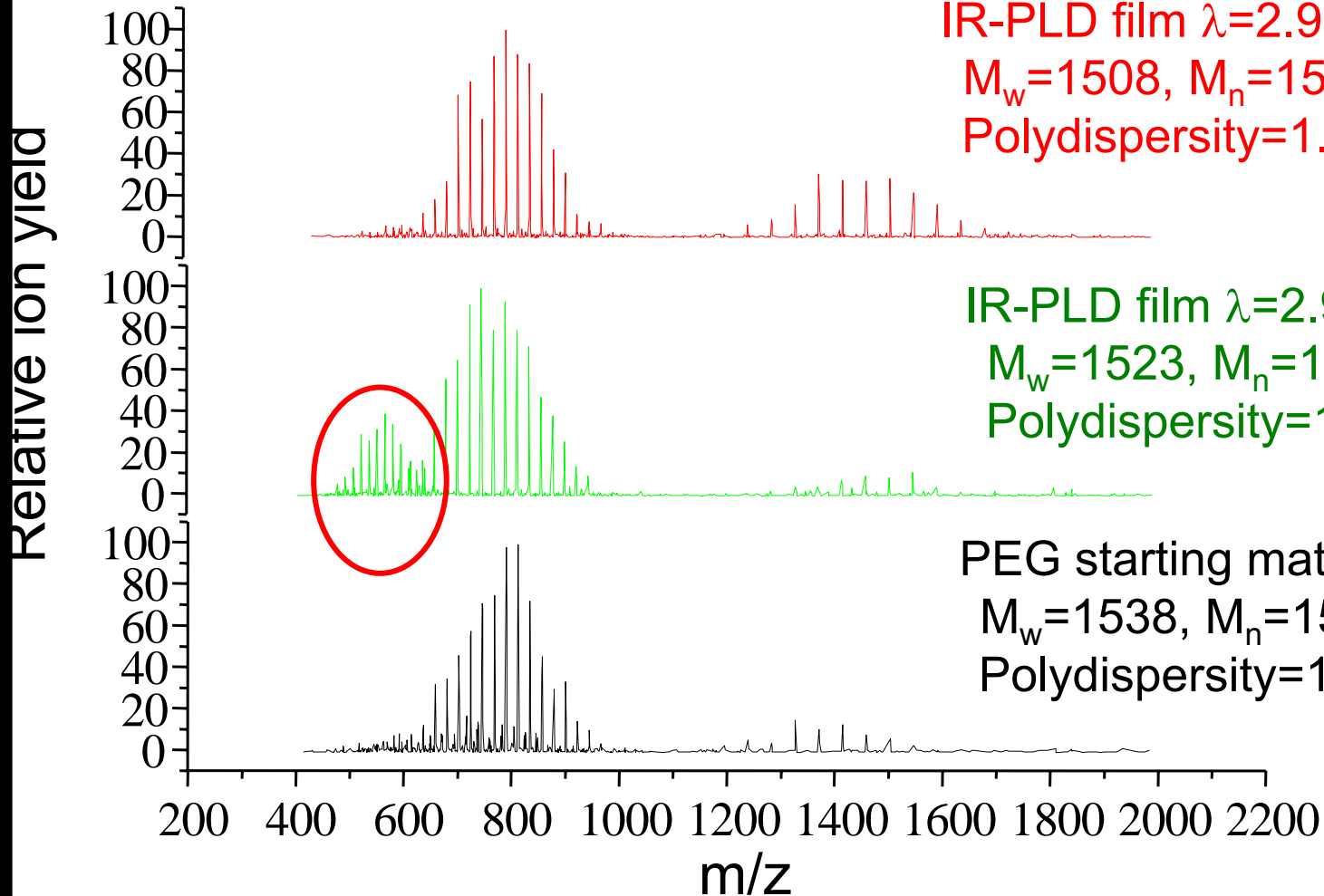
Off-resonance IR is also bad

Electrospray ionization mass spectra of PEG (1450) films

IR-PLD film $\lambda=2.9 \mu\text{m}$
 $M_w=1508, M_n=1501$
Polydispersity=1.01

IR-PLD film $\lambda=2.9 \mu\text{m}$
 $M_w=1523, M_n=1507$
Polydispersity=1.01

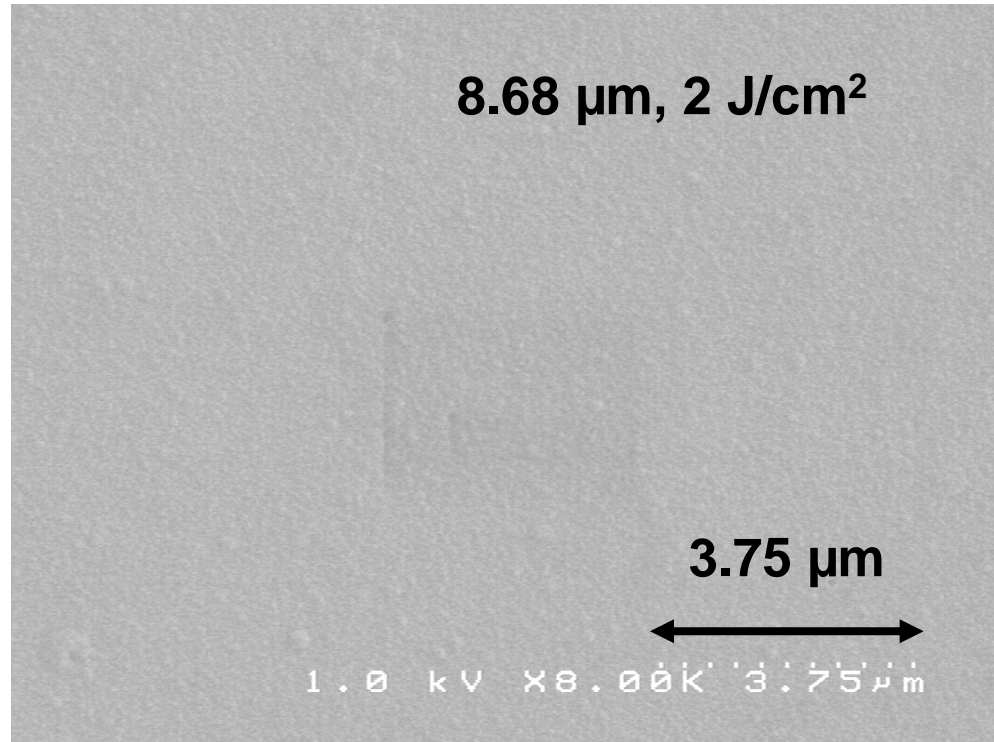
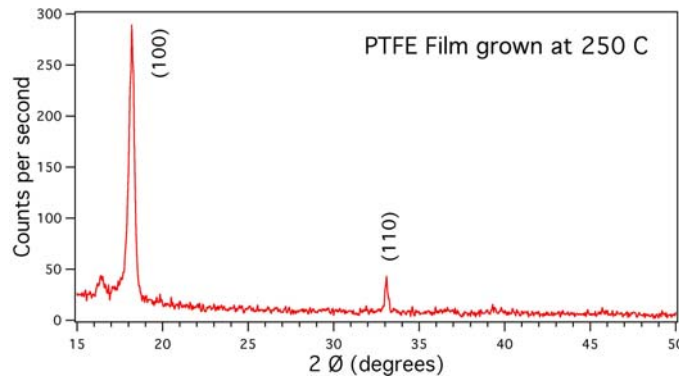
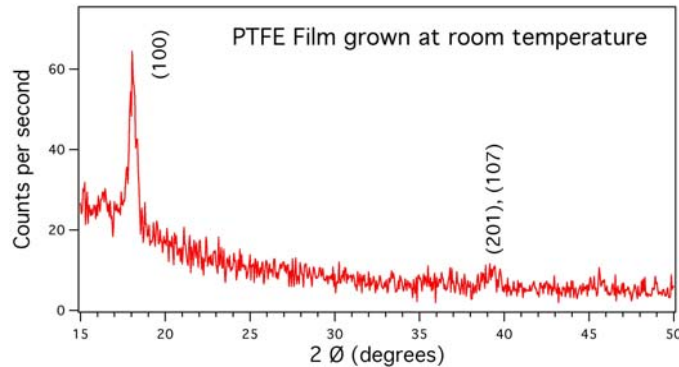
PEG starting material
 $M_w=1538, M_n=1500$
Polydispersity=1.03





RIR-PLD PTFE Films on Si Substrates

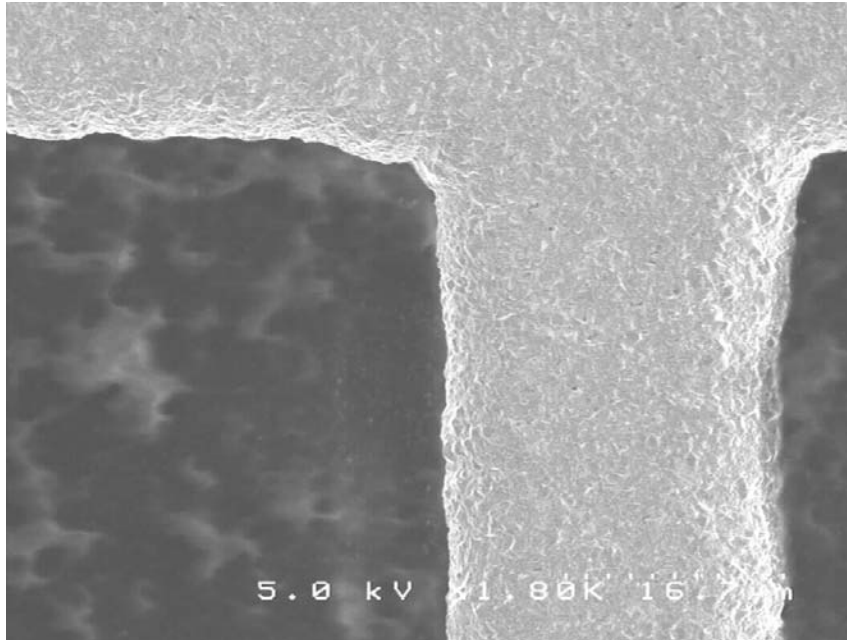
Why PTFE films? Dielectric properties, low friction coefficient, chemical inertness, biocompatibility, ...



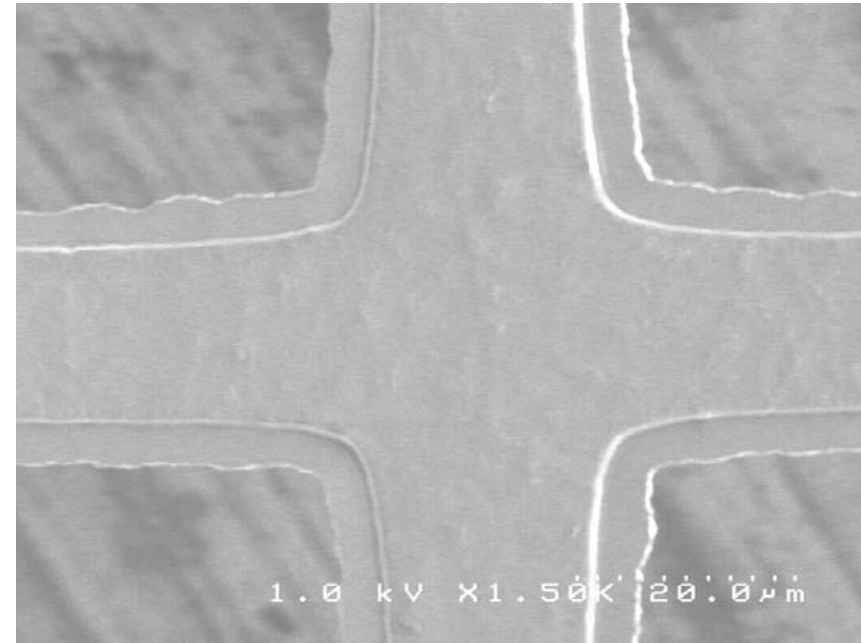
Films have no large scale particulates, **RMS roughness = 12 nm**. XRD shows increased crystallinity, smoothness with moderate heating



Uncoated Ni wire mesh

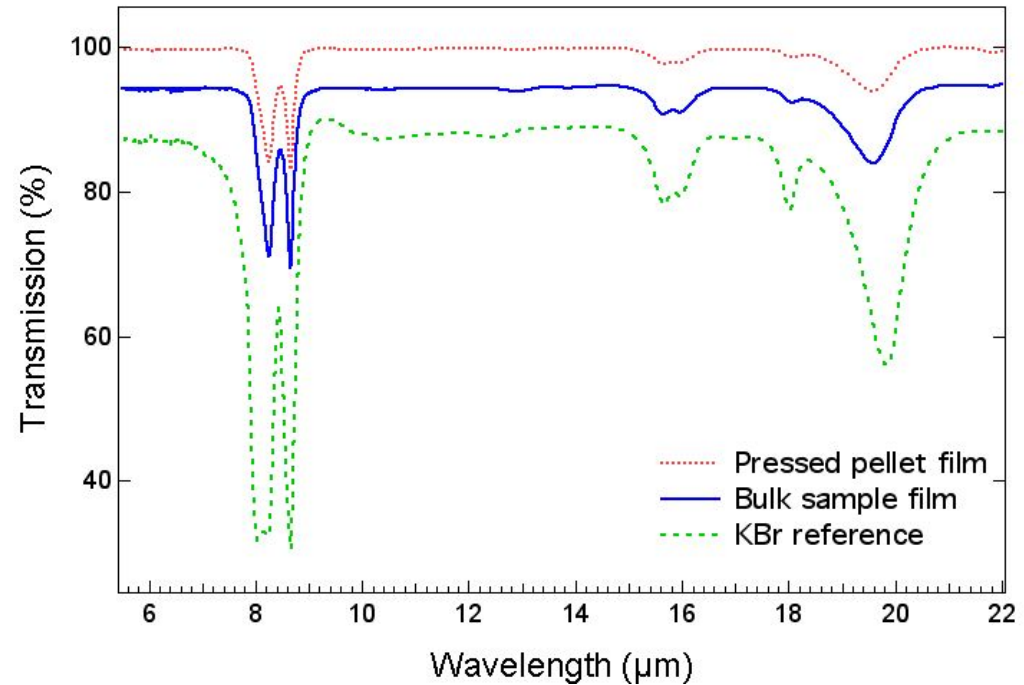
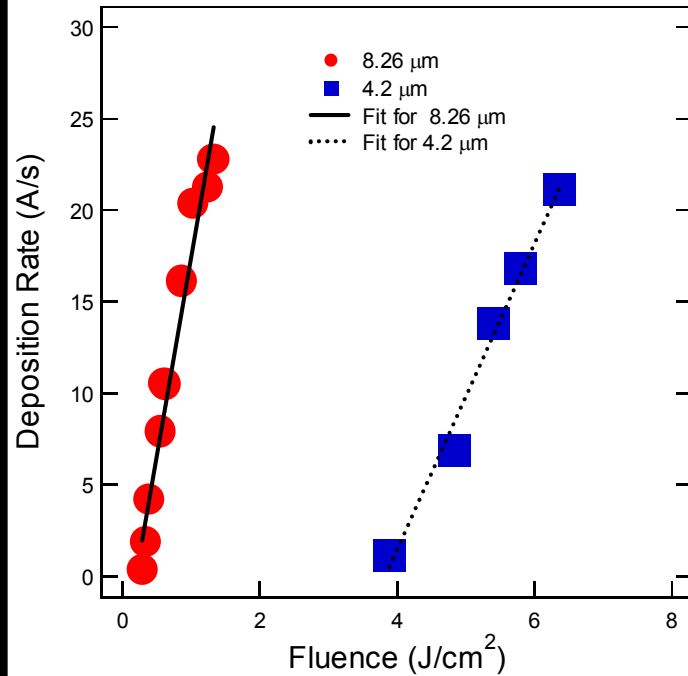


Coated with 200 nm PTFE



- Deposited 135-nm thick coating in 5 min at $F=0.5 \text{ J/cm}^2$, $\lambda=8.26 \text{ } \mu\text{m}$. No significant particulate formation.
- Note sharp edge of PTFE film on Ni mesh structure.

RIR-PLD of poly(tetrafluoroethylene)



- Penetration depth is 1.5 μm at 8.26 μm, 30 μm at 4.2 μm, suggesting strong vs weaker local excitation, respectively.
- One-dimensional heat-flow calculations show that T_{melt} is not reached, but final target temperature higher at 4.2 μm.
- Low threshold at 8.26 μm corresponds to smoothest films; at 4.2 μm, ablation may be dominated by droplet formation.

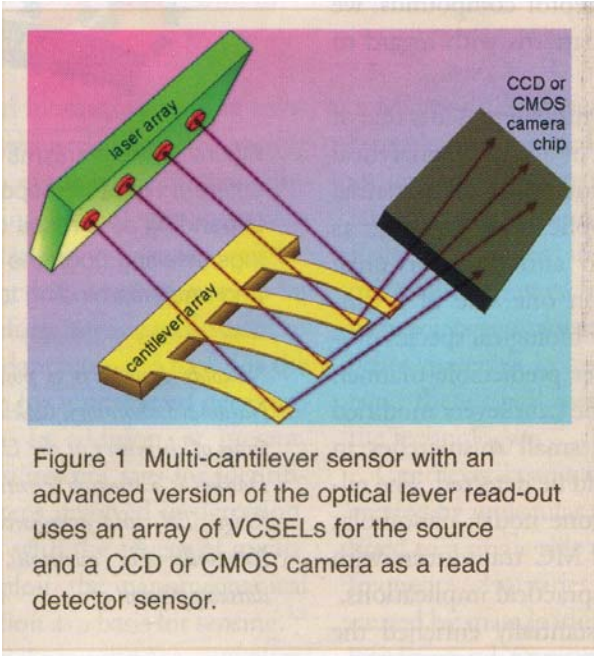


Figure 1 Multi-cantilever sensor with an advanced version of the optical lever read-out uses an array of VCSELs for the source and a CCD or CMOS camera as a read detector sensor.

- Cantilever sensor
- Optical detection
- Mechanical or chemical response, depending on mechanism

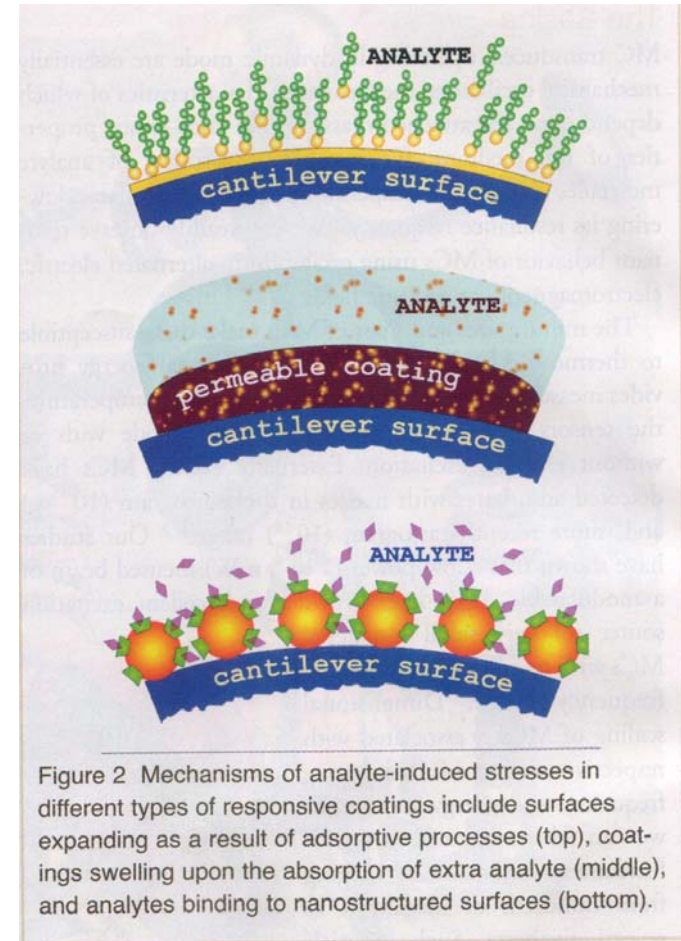
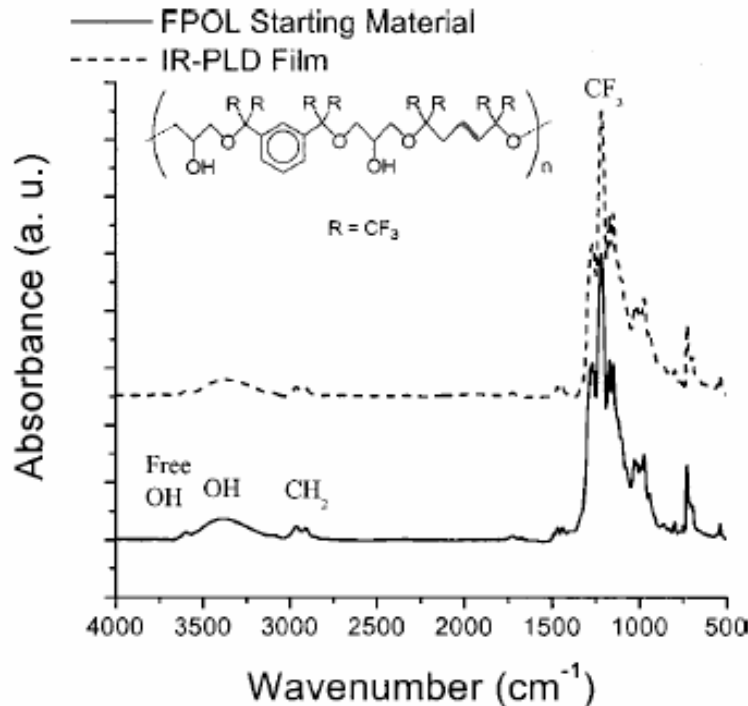


Figure 2 Mechanisms of analyte-induced stresses in different types of responsive coatings include surfaces expanding as a result of adsorptive processes (top), coatings swelling upon the absorption of extra analyte (middle), and analytes binding to nanostructured surfaces (bottom).

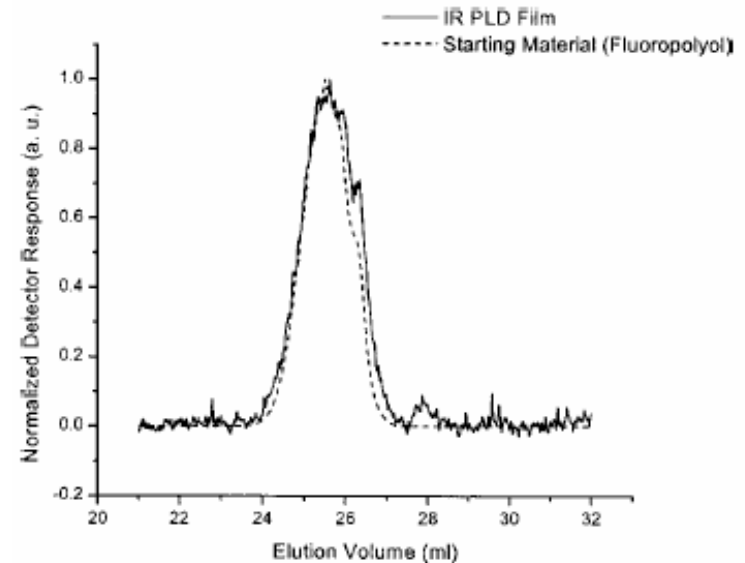
Functionalized polymer deposition

Appl Phys Lett **79**, 2847 (2001)

- ☒ SAW or cantiliver sensors require coatings of precise thicknesses
- ☒ Solubility and selectivity controlled by pendant groups attached to backbone



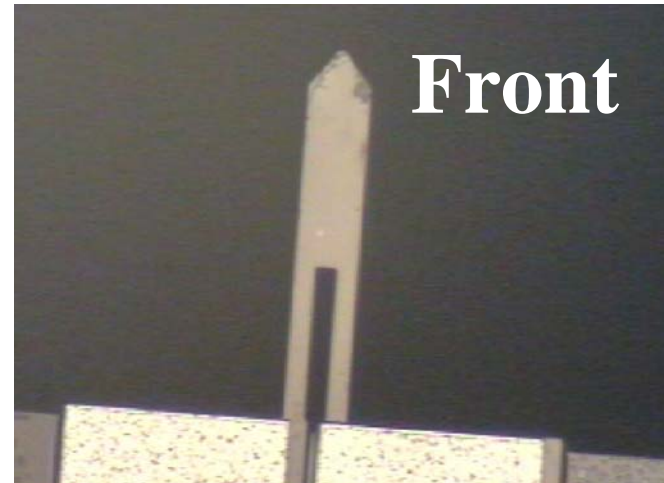
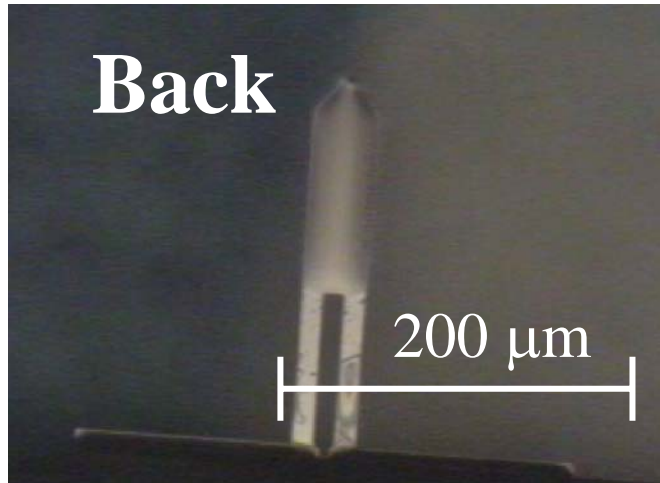
- ✧ Nearly identical FTIR spectra of target and film at 2.90 μm (O-H stretch)



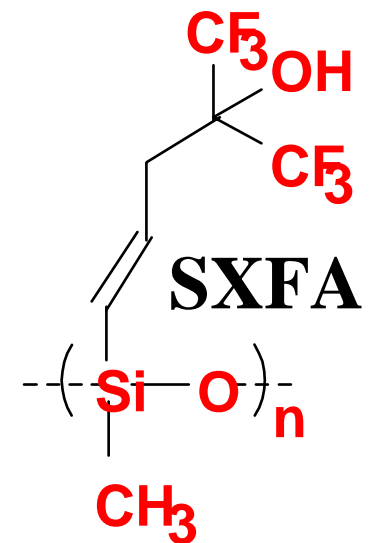
- ✧ GPC gives polydispersity M_w/M_n is 1.24 for native material, 1.21 for the PLD film.
- ✧ Deposition rate is 0.3 nm/macropulse - or 30x that of UV-MAPLE.



Microcantilevers for sensors



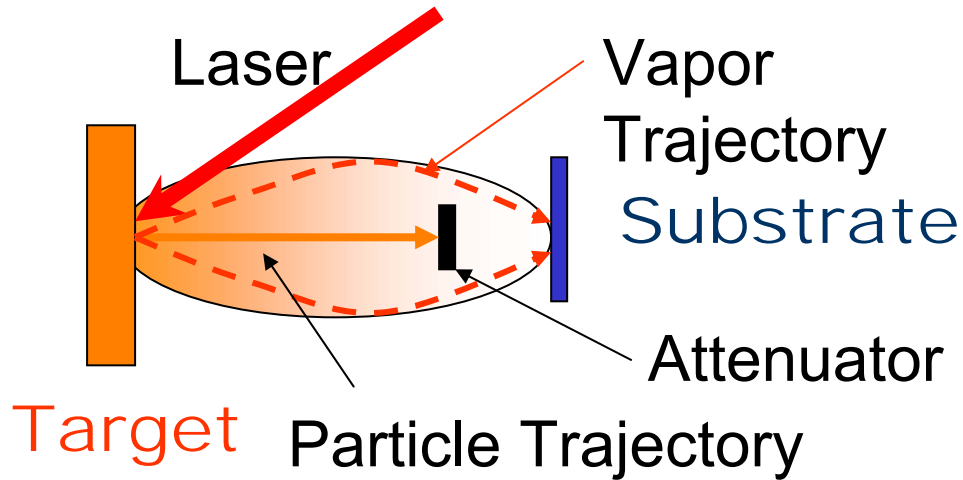
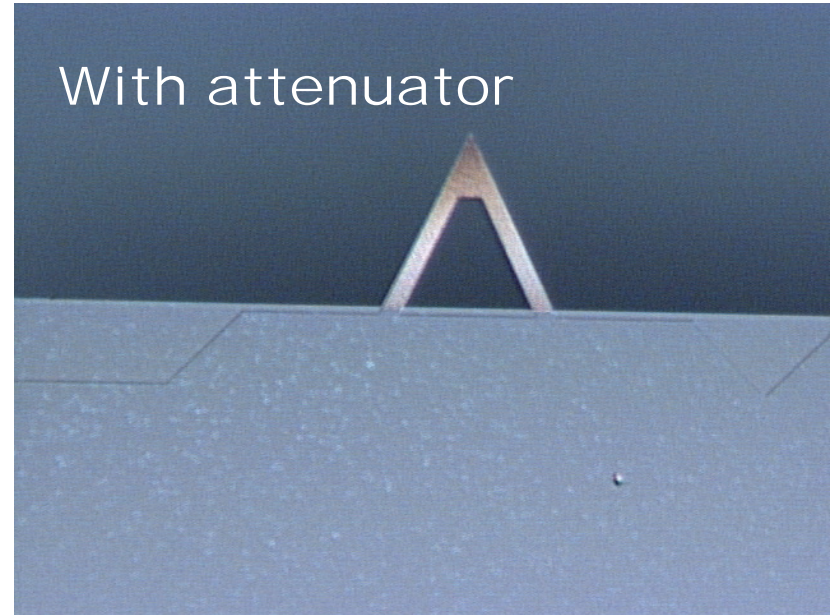
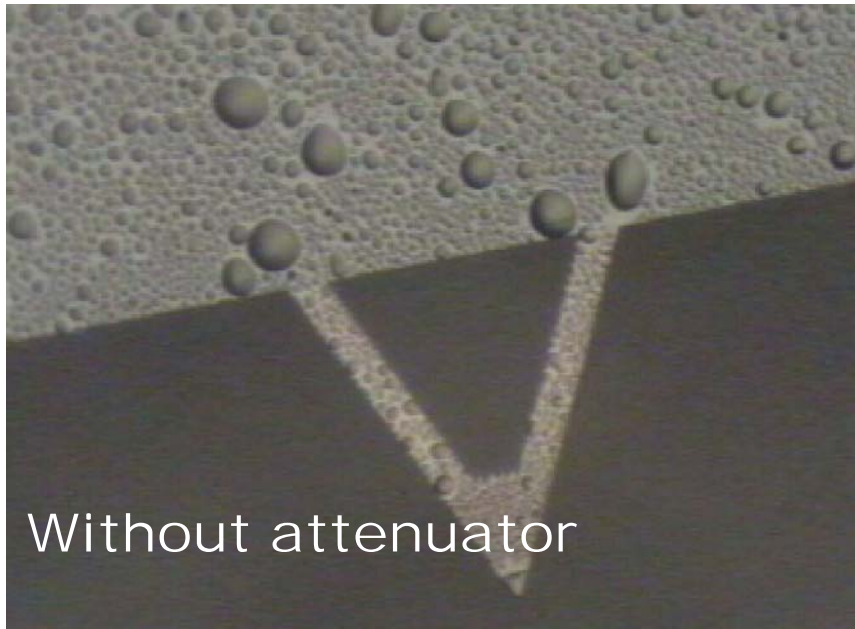
- Strain based sensor **REQUIRES** coating only one side
- RIR-PLD used to deposit 500 nm of SXFA
- Successful challenge with DMMP simulant vapor
- Device requirements **can not** be met by any other organic film technology (solvents, thickness control)





Improved carbosilane morphology

APS April 2006 Meeting — Dallas TX



**Pulsed laser passive filter
deposition system**

US Patent 5,458,686

Pique et al., NRL, 1995

23 April 2006

25

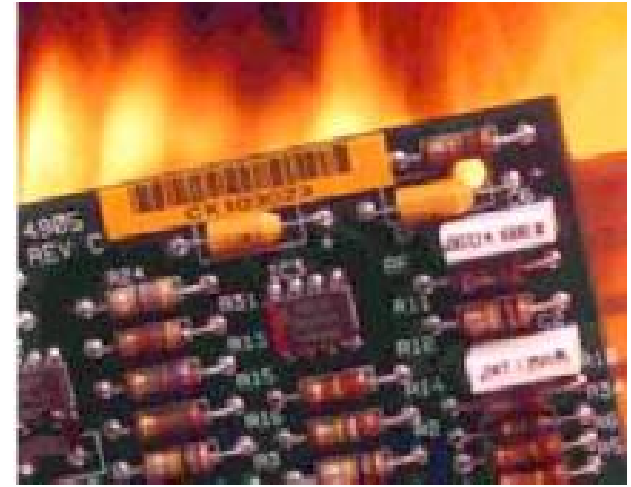
42



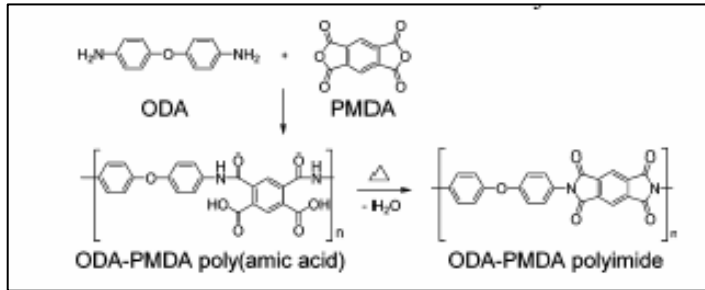
Polyimide - a thermoset polymer



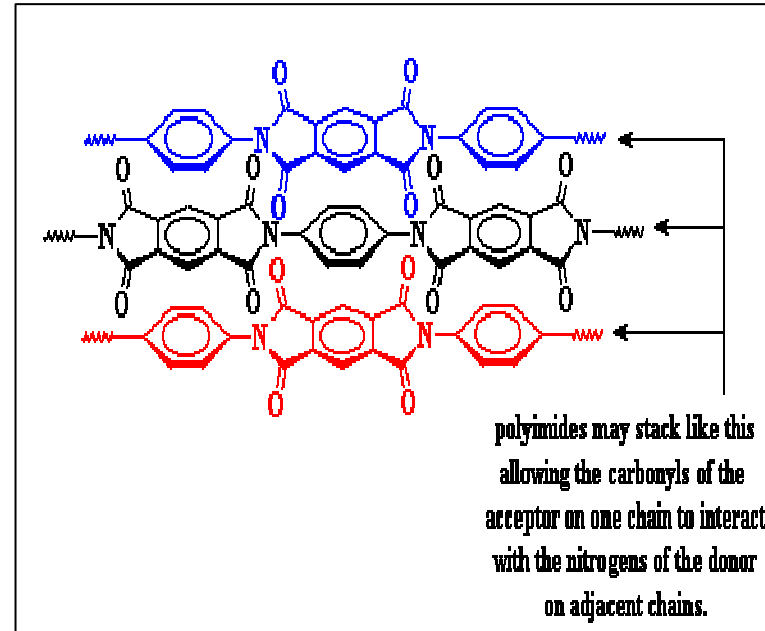
Kapton®
polyimide film



- Withstands huge extremes of temperatures
- Can be fabricated in many different forms
- Excellent insulating properties
- Chemically inert, mechanically hard
- Widely used in electronics industry

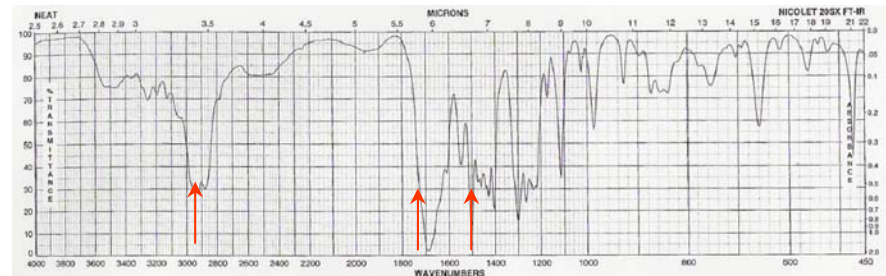
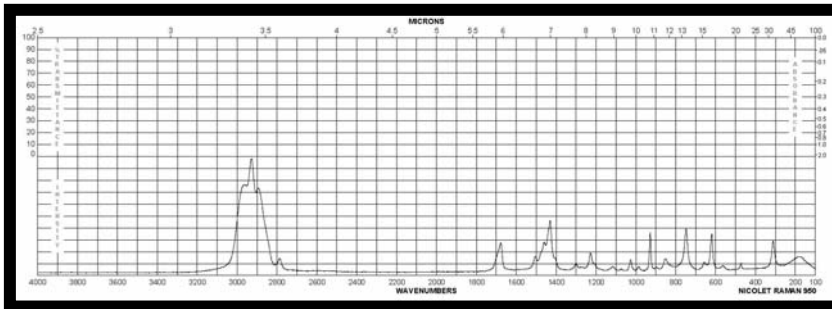


- Normal synthesis requires heating to make “thermoset”
- RIR-PLD with FEL attempted at 3.45, 5.95 and 6.67 μm (see arrows)



n-methyl pyrrolidone (NMP)

FTIR spectrum of PAA in MNP



Plume photography of MNP and PAA-MNP

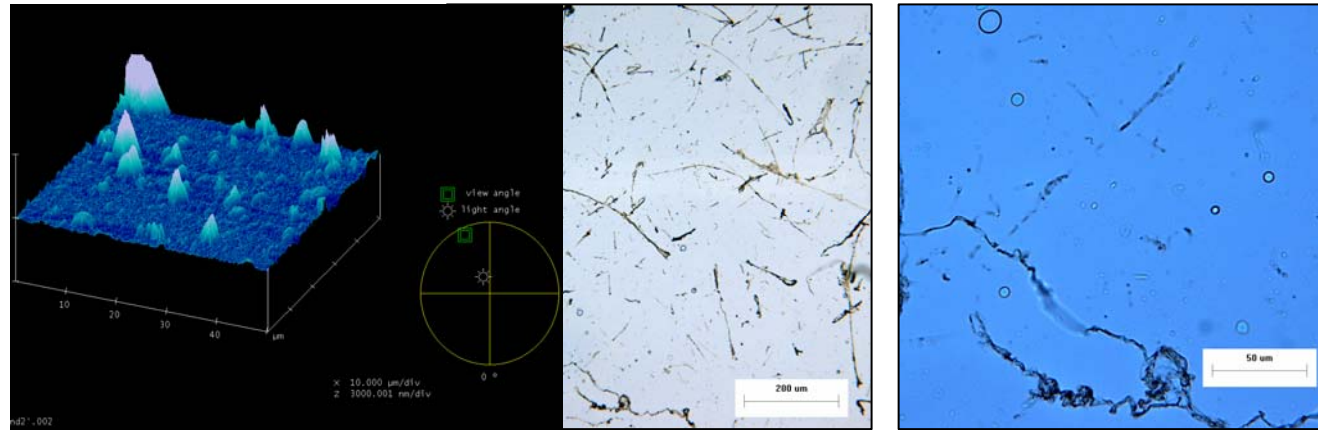


Ablation plume evolution, FEL wavelength $3.45 \mu\text{m}$ fluence $\sim 3\text{J}/\text{cm}^2$:
Top NMP; bottom, PAA solution

- Clear difference between the NMP matrix solution, and the more viscous NMP-PAA solution.
- Ablation phenomenology strongly resembles the behavior of liquids (*à la* Vogel, Jansen, Venugopalan)
- Suggests an important role for **viscosity** in the non-destructive ablation of polymers ...

Results of RIR-PLD of PAA in NMP

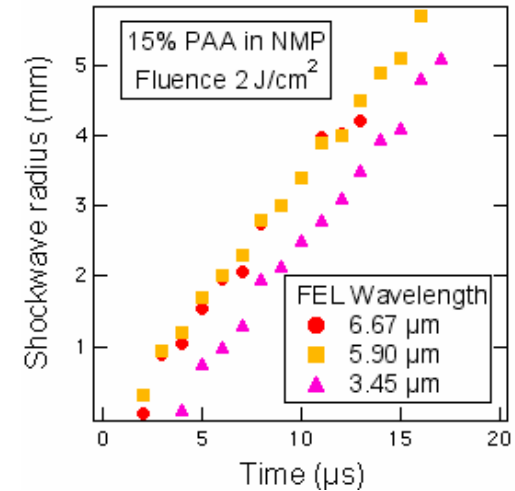
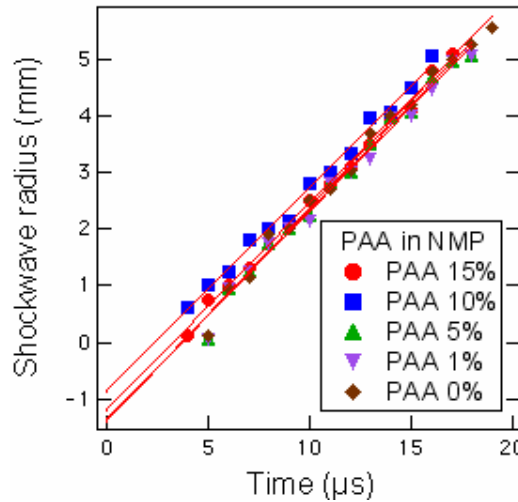
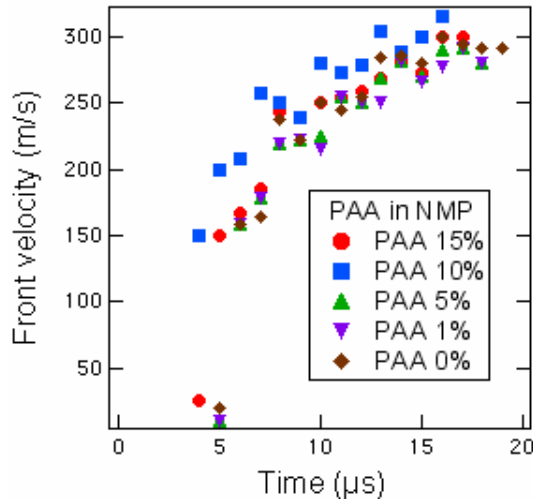
QuickTime™ and a TIFF (Uncompressed) decompressor are needed to see this picture.



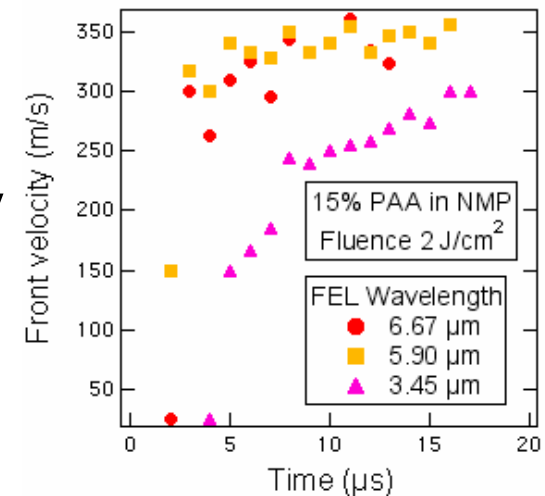
Thick RIR-PLD film

RIR-PLD in vacuum

- Threshold for deposition is $\sim 0.5 \text{ J/cm}^2$ in vacuum and in air. (Scale bar above, right is $200 \mu\text{m}$.)
- Photomicrographs show string (only in vacuum) and droplet (in air and vacuum) morphologies for low fluence.
- At higher fluence, films become thicker, but are still uncured until heating.
- Post-deposition methanol wash removed PAA-NMP.
- **Curing of the PAA only occurred following heating!**



- Data from shadowgraph experiments carried out in air as function of delay time
- Shadowgraph apparatus calibrated by machinist's ruler
- At any given wavelength, shockwave velocity is relatively independent of PAA concentration
- Clear dependence of velocity on wavelength; note that 3.45 μm ablation produces slower shock wave.



- Cost Driver

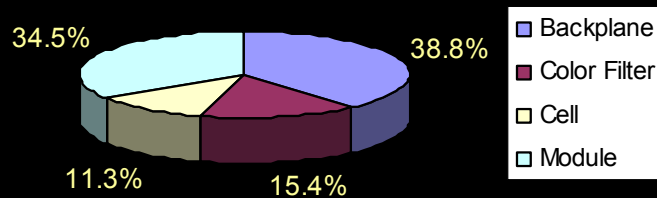
Year	2004	2007	2010
Fab cost (\$/sq in)	5.00	1.00	0.50

- Source: U.S. Display Consortium Roadmap

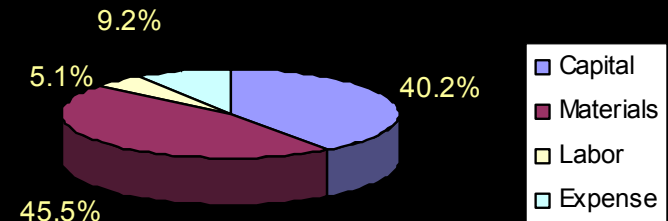


- Cost Breakdown

15" LCD Cost Breakdown

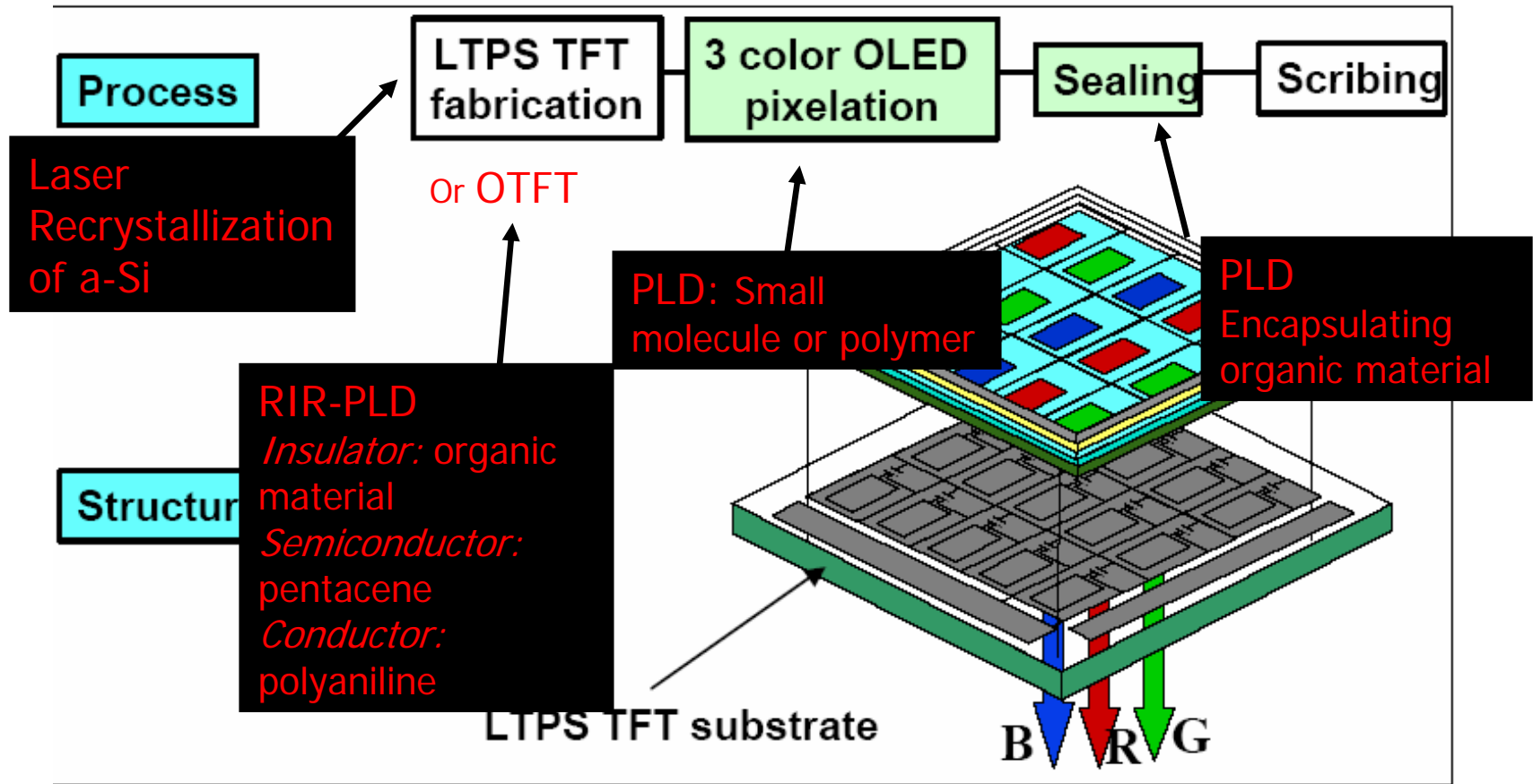


15" LCD Cost Breakdown

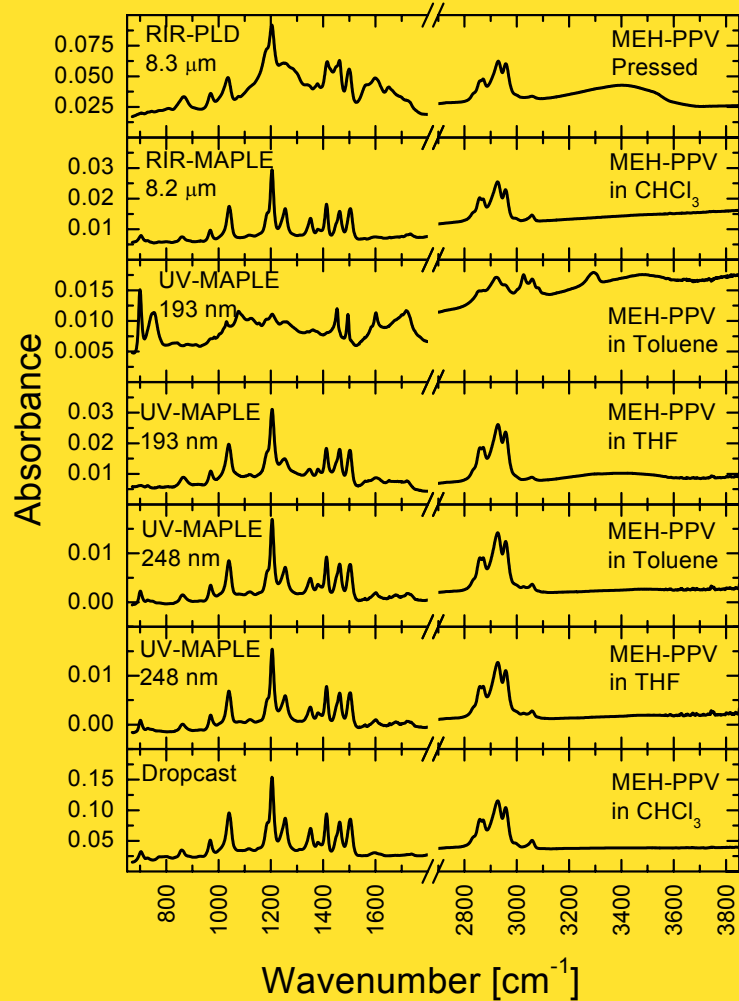


- Conclusion: Improvements that focus on (1) simpler fabrication process and (2) reduced material consumption will very likely be of interest to industry.

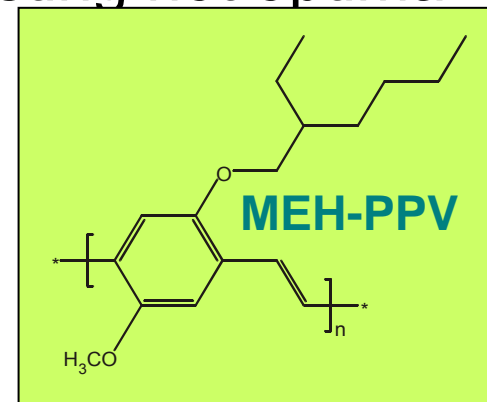
RIR-PLD for OLED processing ...



RIR-PLD of MEH-PPV

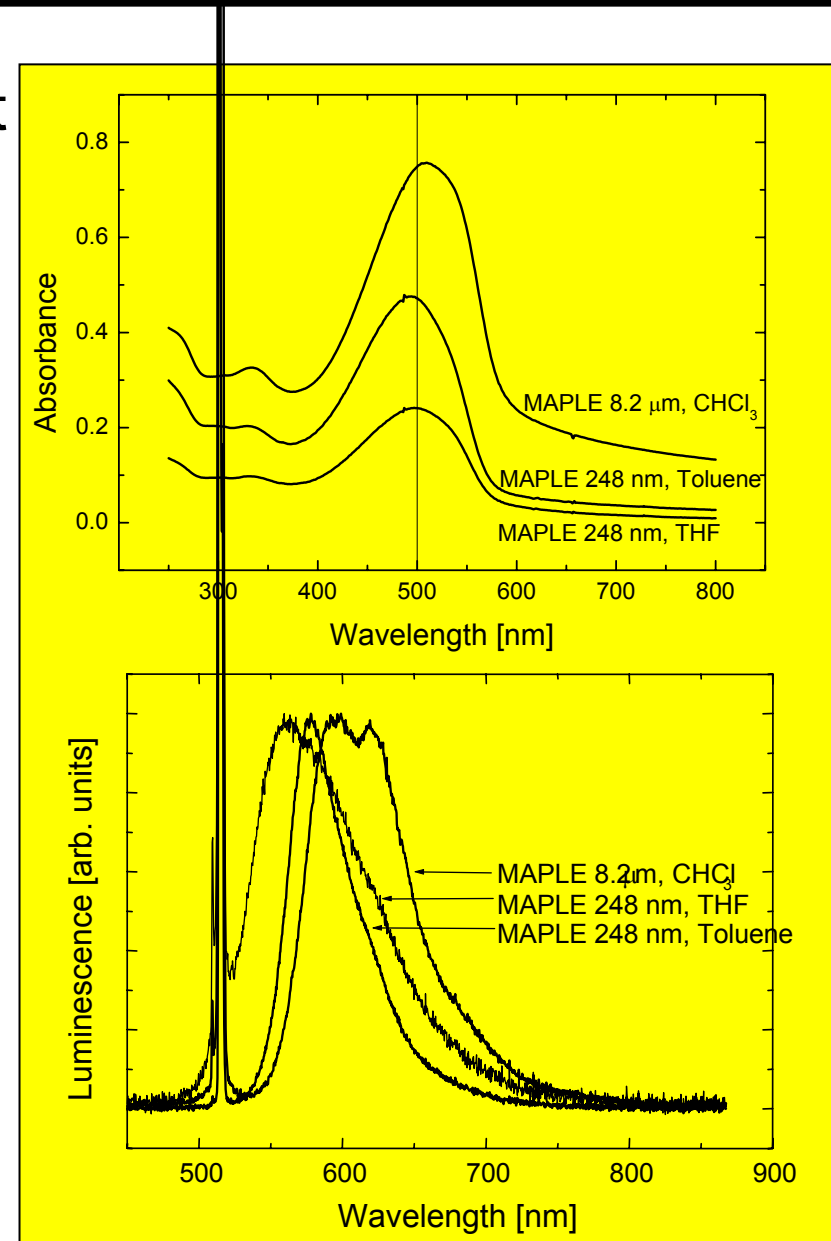


- Poly[2-methoxy-5-(2'-ethyl-hexyloxy)-1,4-phenylene vinylene]
- **MEH-PPV** to physicists!
- Organic light emitter (flat-panel and mobile device displays).
- Spin-coating and drop-casting not optimal.

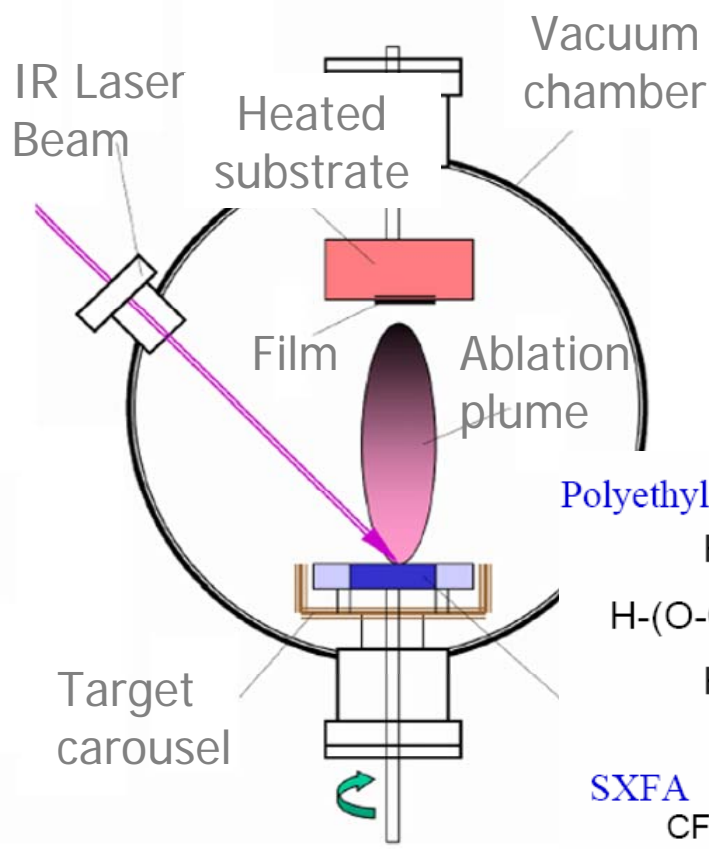


Reference: Toftmann *et al.*, *Thin Solid Films* (EMRS-2003)

- Photoluminescence (pump at 514 nm), peaks normalized to maximum above that wavelength.
- Little to no shift in uv-vis absorbance, but ...
- Substantial changes in luminescence spectrum with wavelength and solvent.
- Other researchers observed correlations between peak shifts and solvent, as well as film morphology.
- Smooth films grown at 193 nm and by RIR-PLD, but UV-PLD films are too thin.

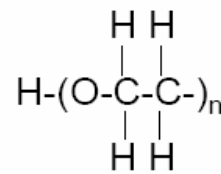


RIR-PLD demonstrated on ...

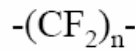


RIR-PLD collaboration (Bubb, Haglund et al., Horwitz) at the Vanderbilt FEL has demonstrated low-temperature IR-laser deposition of large, thermally labile **thermoplastic** and **thermoset** polymers for a wide variety of applications.

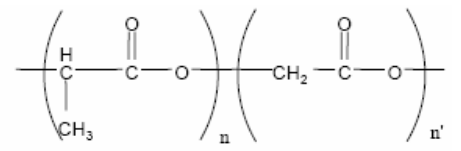
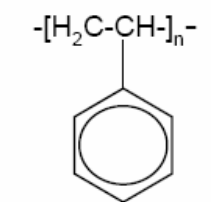
Polyethylene Glycol



Teflon

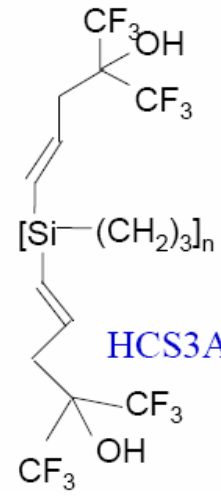
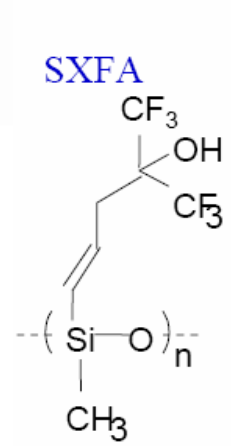


Polystyrene



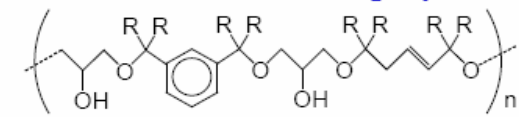
poly(DL-lactide-co-glycolide) (PLGA)

SXFA

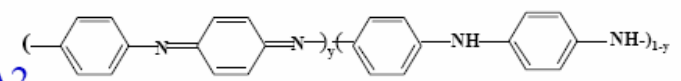


HCS3A2

Fluoropolyol



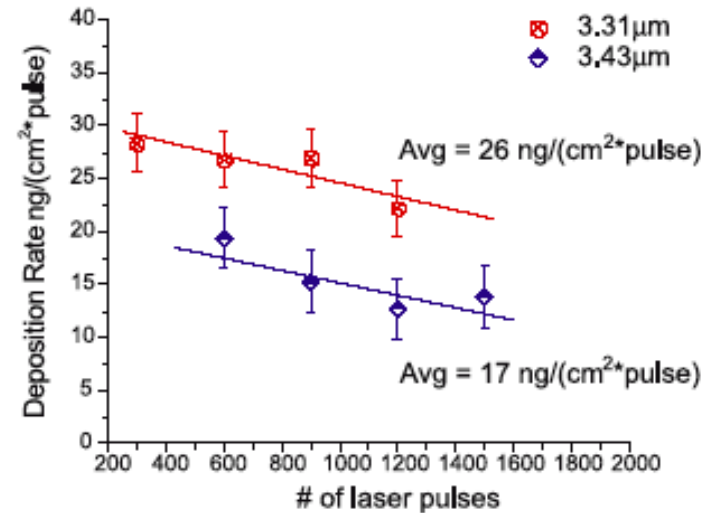
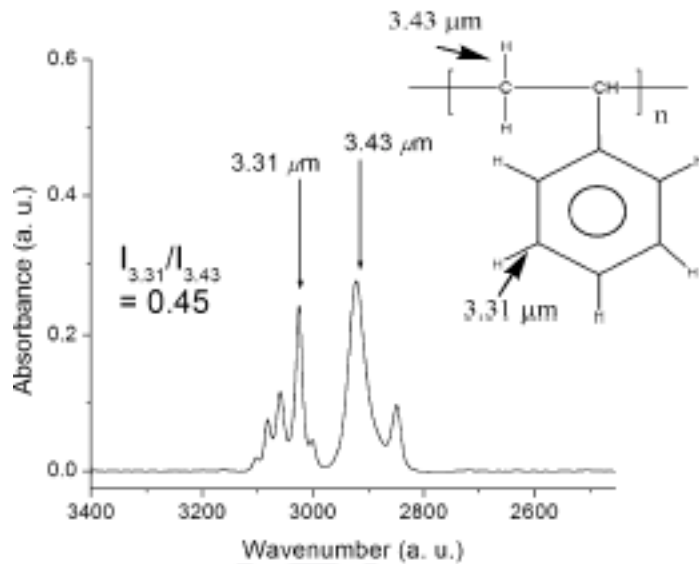
Polyaniline



Versatile technique which preserves chemical structure and function
Electroluminescent polymers for OLEDs

So what have we learned?

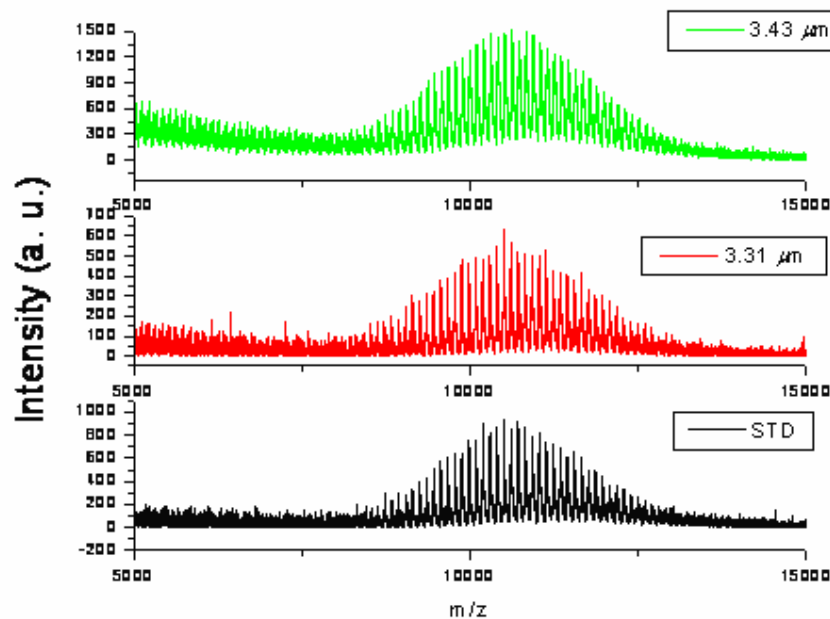
- A new paradigm: resonant infrared pulsed laser deposition (RIR-PLD) of polymers
- Some case studies ...
 - Biomedical applications: PEG, PLGA, Teflon
 - Sensors: fluoropolyol, SXFA
 - Electronic applications: Polyimide
 - Opto-electronic applications: MEH-PPV
- Evidence for low-temperature, non-thermal character of RIR-PLD ... and some thoughts about a substitute for the FEL



- FEL macropulse ablation, fluence $\sim 5 \text{ J}/\text{cm}^2$
- Molecular weight $\sim 10 \text{ kDa}$
- Chain length ~ 100 monomer chain
- $\tau(3.31) \sim 450 \text{ fs}$, $\tau(3.43) \sim 150 \text{ fs}$
- *Applied Physics A* **83**, 147 (2006)



What's happening?

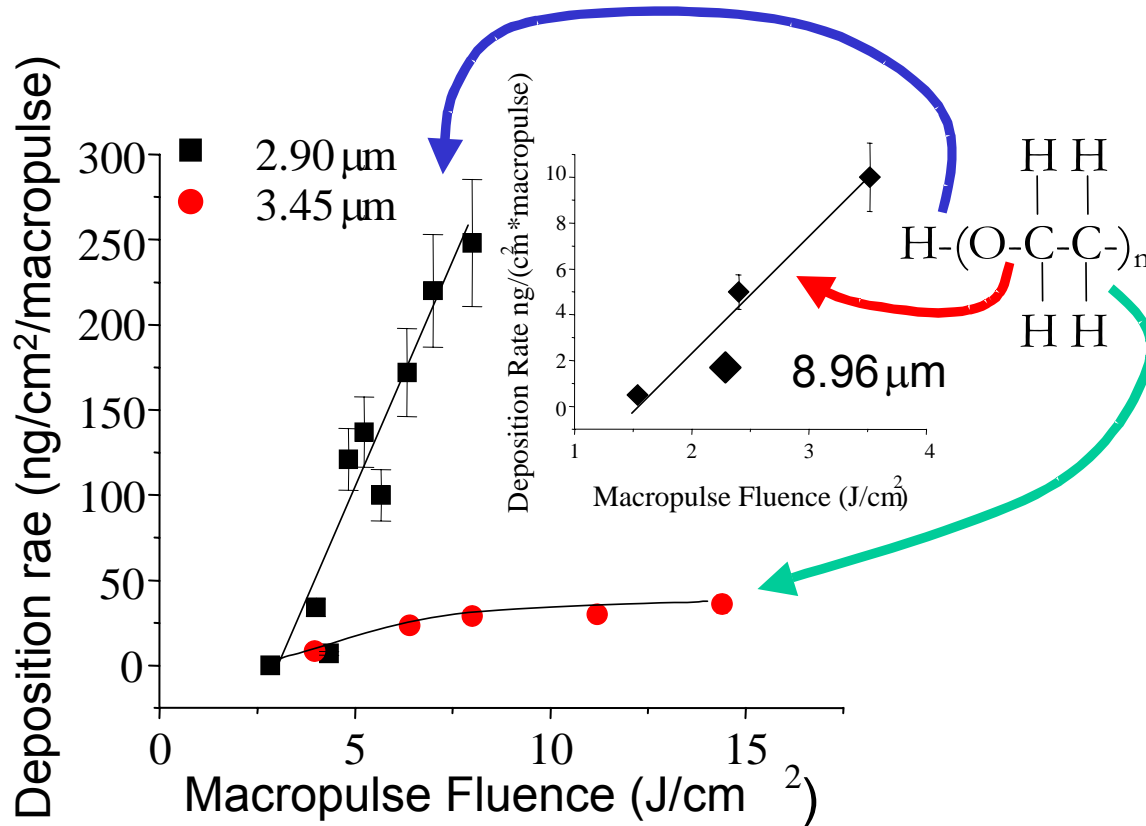


	3.31 μm	3.43 μm
α (cm ⁻¹)	1280	1450
L_p (μm)	7.8	6.9
D_{thermal} (cm ² /s)	10 ⁻⁴	10 ⁻⁴
c_{sound} (m/s)	2200	2200
$\tau_{\text{thermal}} = (L_p)^2$ (ms)	5.7	4.5
$\tau_{\text{pressure}} = L_p/c_s$ (ns)	3.5	3.1
η/η_0	10 ⁻²	10 ⁻²

- Fragmentation usually from backbone modes
- Gentle bond-breaking from **side-chain** stretch
- Thermally, but not pressure, confined
- Dramatic decrease in viscosity (Vogler-Fulcher)
- Hydrogen bond-breaking between polymers

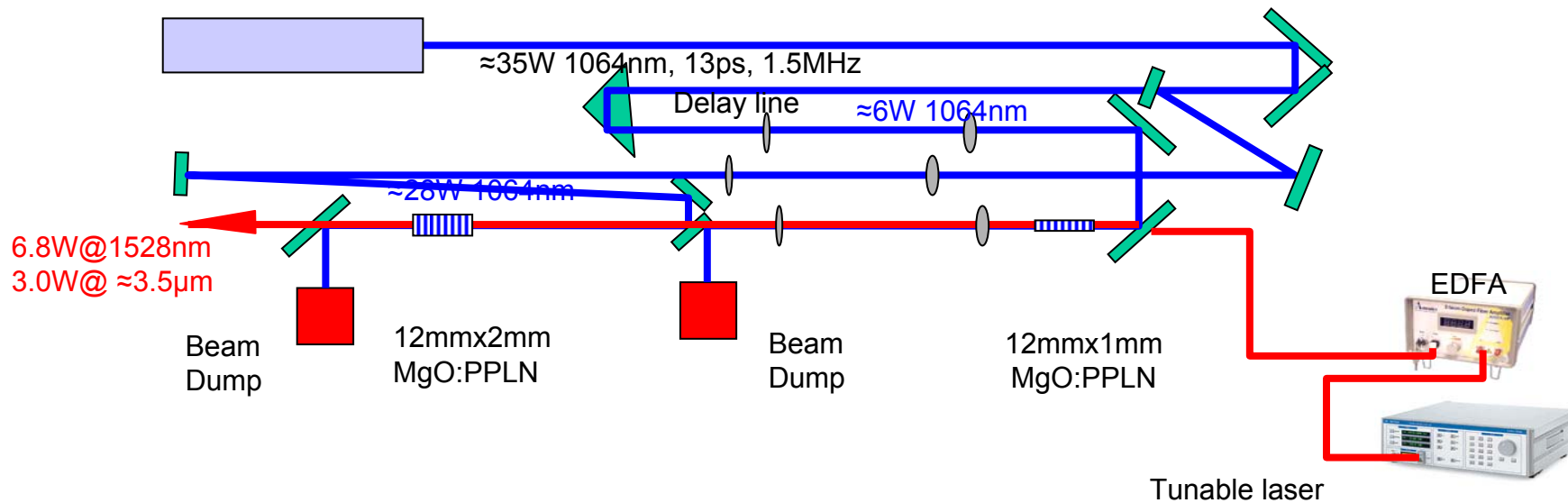


Evidence for mode-specific response



J Appl Phys 91, 9809 (2002)

- Ablation efficiency not correlated with IR absorption strength
- Ablation efficiency correlates with inter-molecular bond (O-H)
- Weak absorption also correlates with least bond scission



- All commercial components, all solid-state turnkey system, tunable, high average power
- In operation for over a year at Australian National University (Barry Luther-Davies)
- The challenge: to get beyond 4 μm!

- A new paradigm for pulsed laser deposition
 - Use tunable IR light to control penetration depth
 - Use high-intensity, low-energy, high pulse-repetition rate laser
 - Gives low-temperature, solvent-free, conformal deposition
- Applications potential demonstrated for
 - Many technologies (MEMS, biotechnology, sensors, OLEDs ...)
 - Thermoplastic and thermosetting polymers
 - Polymers that cannot be deposited in liquid phase (e.g., Teflon[®])
- RIR-PLD is intrinsically a low-temperature process
 - Poly(amic acid) does not cure during ablation
 - Modest temperature rise, but large viscosity change
 - Mode selection influences ablation yield and fragmentation
- Next steps: photoacoustic measurements, more detailed characterization of transport properties, ellipsometry, hardness, patterning, integrating with plasmonics ... above all, performance verification



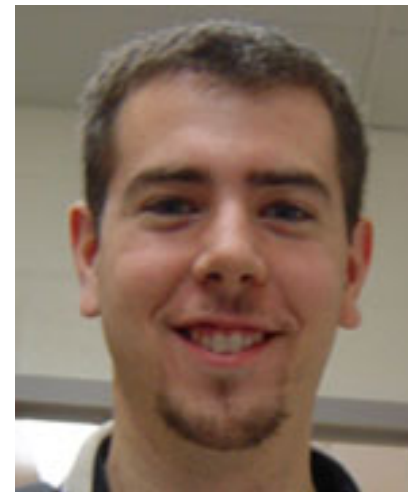
Thanks to the heavy lifters ...



Nicole Dygert



Stephen Johnson



Ron Belmont



Ken Schriver

Supported by the Naval Research Laboratory, the Medical Free-Electron Laser Program administered by the Air Force Office of Scientific Research and the National Science Foundation (IGERT)

And about the Doorknob Principle: “It warn’t so much what I didn’t know what hurt me, but what I knowed that warn’t so.”

(Huck Finn)